

Measurements of Magnetic Field Penetration of Materials for Superconducting Radiofrequency (SRF) Cavities

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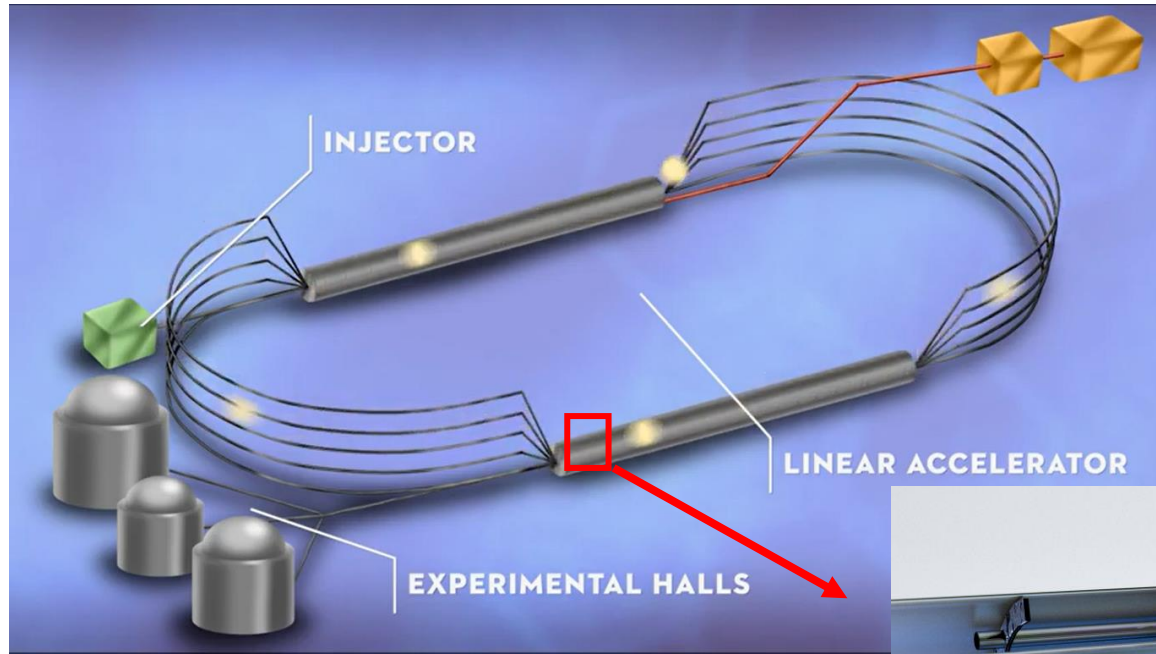
²Thomas Jefferson National Accelerator Facility, USA

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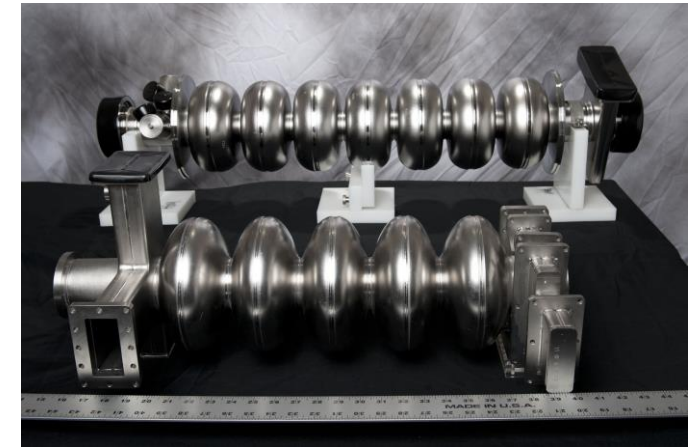
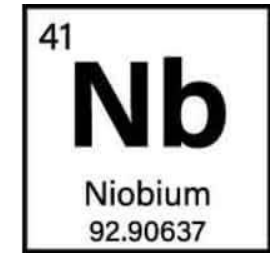
Introduction





CEBAF, Jefferson Lab

Typical SRF cavities are made out of Nb

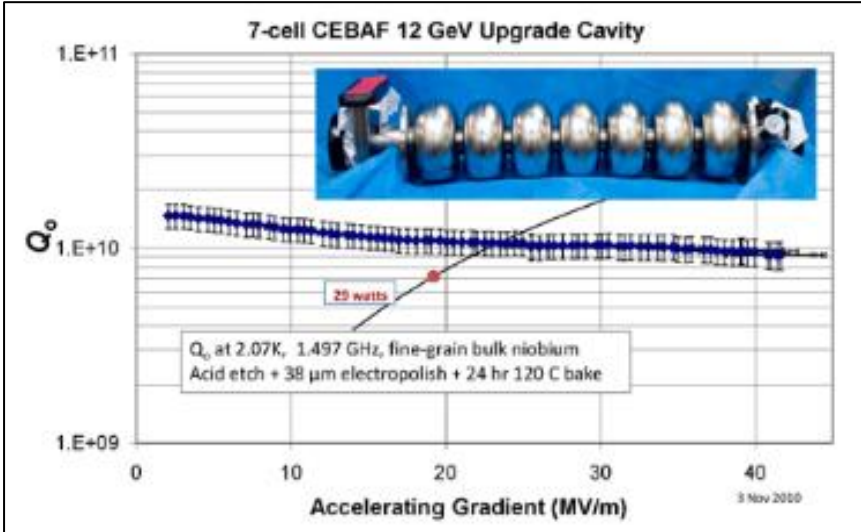
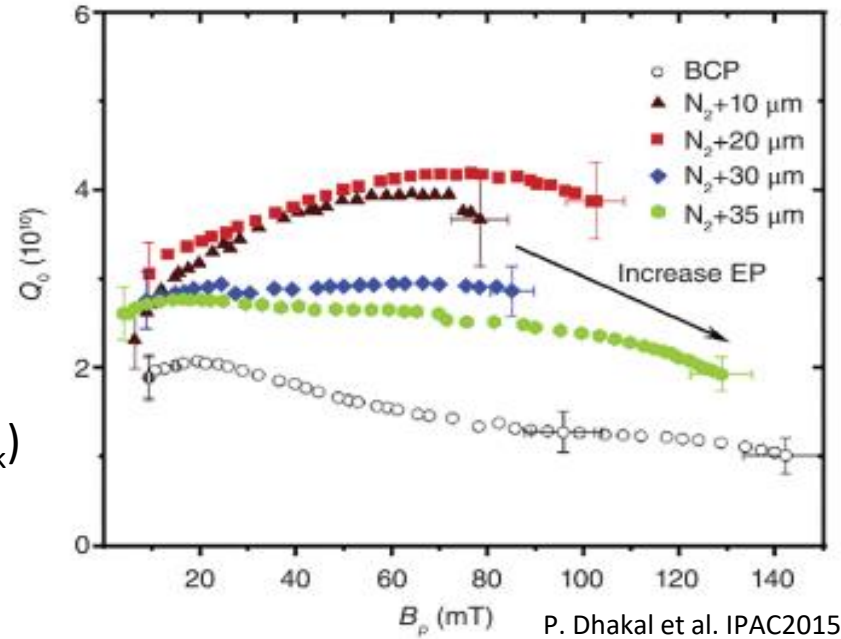


Superconducting RF accelerating cavity is a key component of the particle accelerators which impart energy to charged particles

five- and seven-cell niobium cavities produced at Jefferson Lab's SRF Institute

The key figures of merit that are used to evaluate SRF cavities are,

- Quality factor (Q_0)
 - Peak surface magnetic Field (B_{pk})

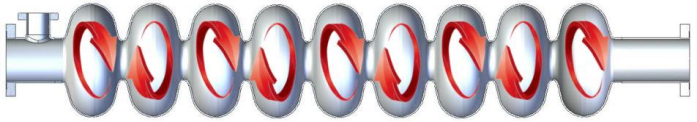


C. E. Reece and G. Ciovati *Rev of Acce. Sci. and Tech.* Vol. 05, pp. 285-312 (2012)

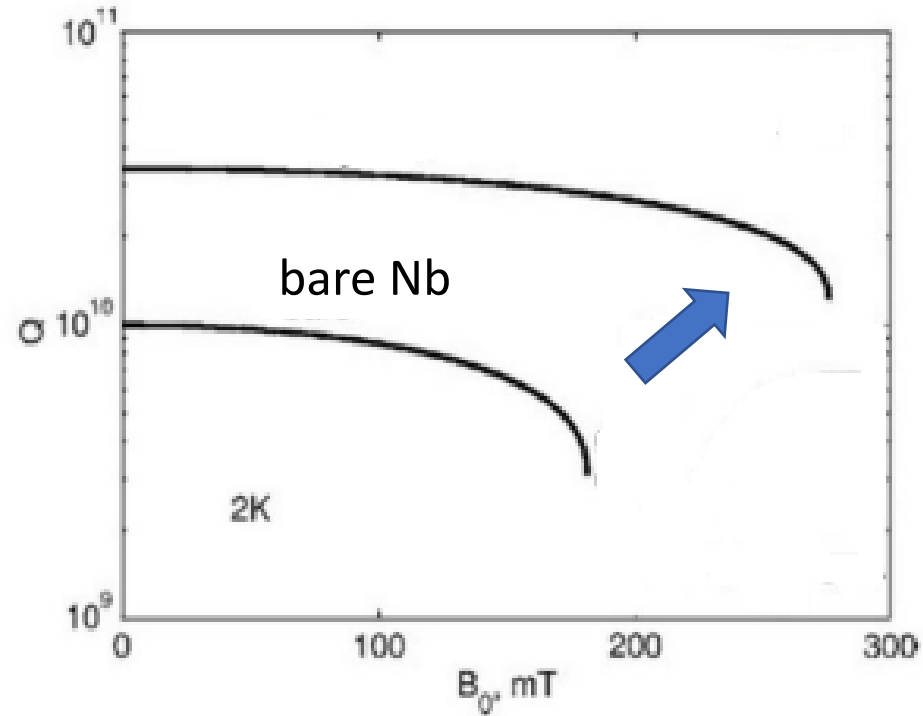
The ratio of the stored energy to power disipation , $Q_0 = \frac{\omega_0 U}{P_c} \propto 1/R_s$

The ratio of the accelerating voltage per cell V to the cell length, $E_{acc}(MV/m) = \frac{V}{L} \propto B_{pk} (mT)$

Peak Surface Magnetic Field



Why new materials ?



Nb SRF cavities can achieve

- High quality factor $\sim 10^{10}$ - 10^{11}
- High Accelerating gradient $\sim 52 \text{ MVm}^{-1}$ (at 1.3–2 K and 1–2 GHz)
- Peak surface magnetic field has reached close to its theoretical limit

$$H_{\text{max}} \approx H_c = 200 \text{ mT}$$

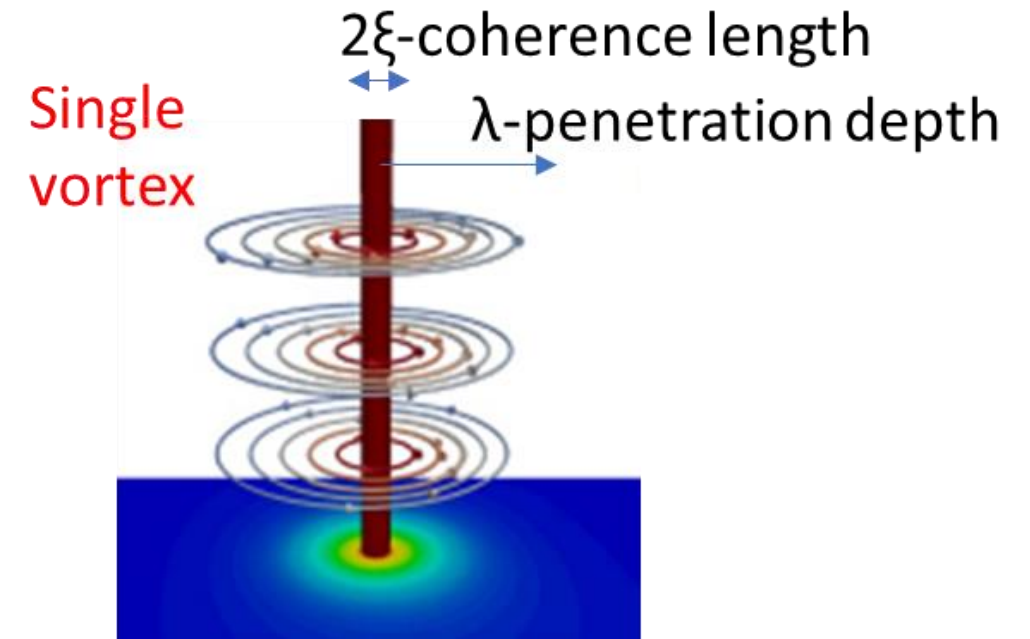
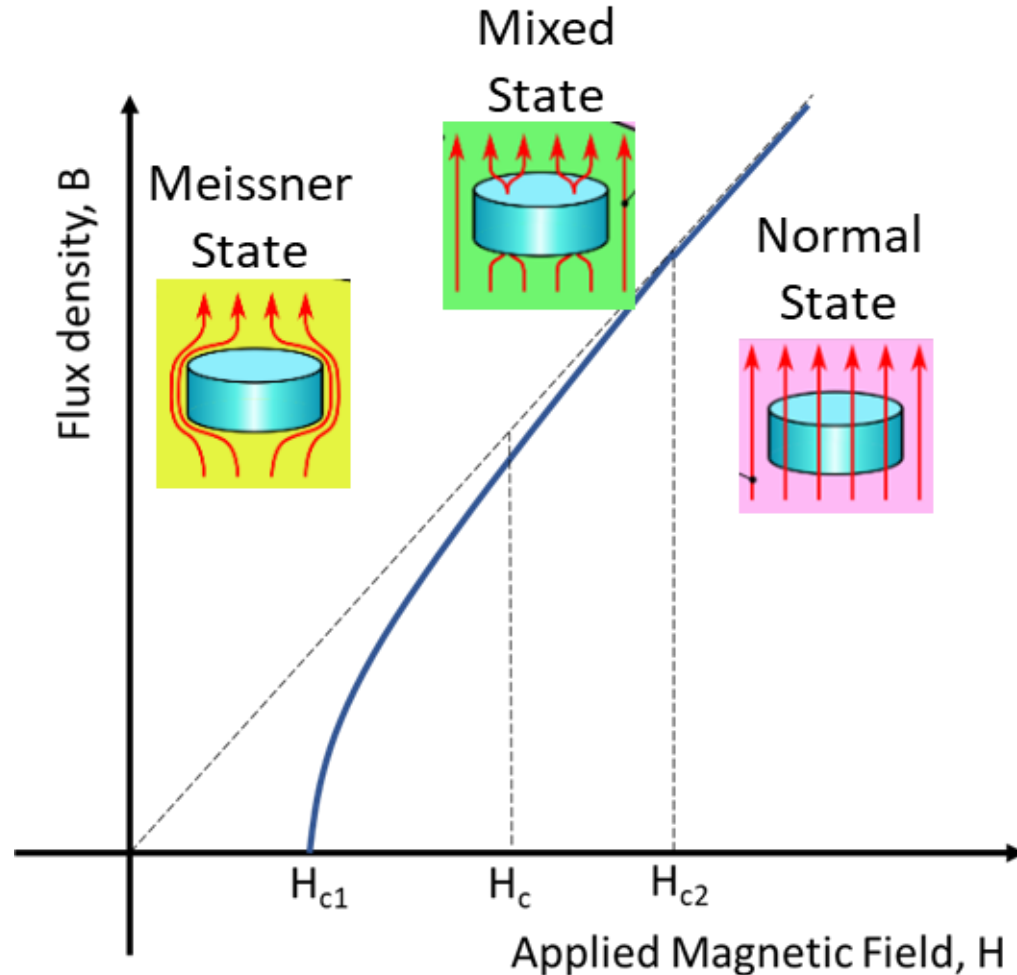
For further improved RF performance of the cavity, materials other than Nb are needed to characterize.

What Choices for New Material ?

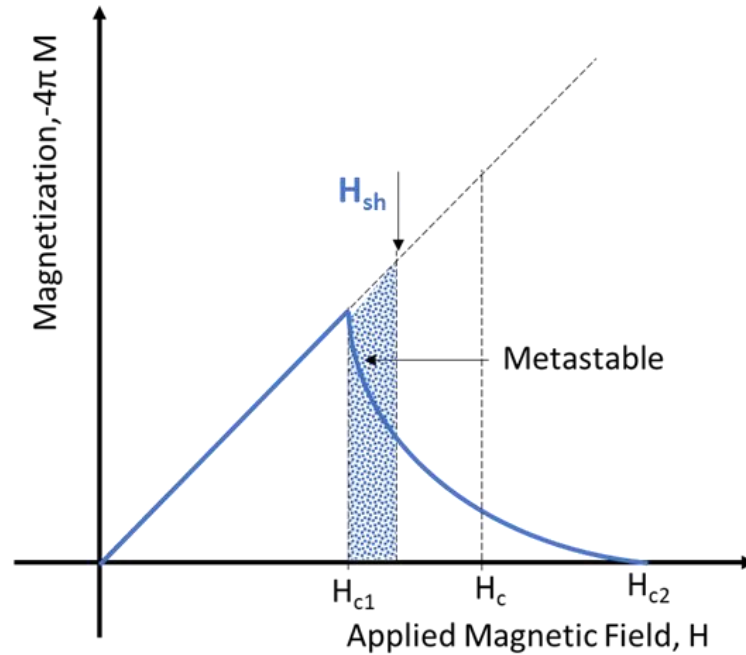
Choices are based on,

- Higher T_c } Low $R_s \rightarrow$ For low RF losses \rightarrow High Quality Factor $Q_o \propto \frac{1}{R_s}$
 - Higher H_c }
 - Higher H_{c1} }
- Increase cavity operation temperature from 2 K to 4 K
- For high accelerating gradients
- $$E_{acc} \propto B_{pk}$$

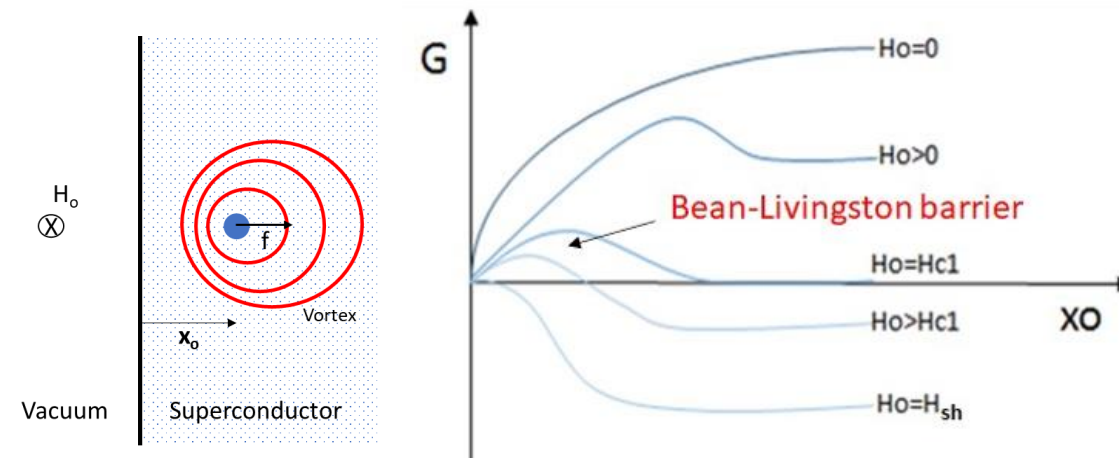
Field Penetration into Type II Superconductor



In Type – II superconductors, the Meissner state can persist metastably above H_{c1} but only up to H_{sh}

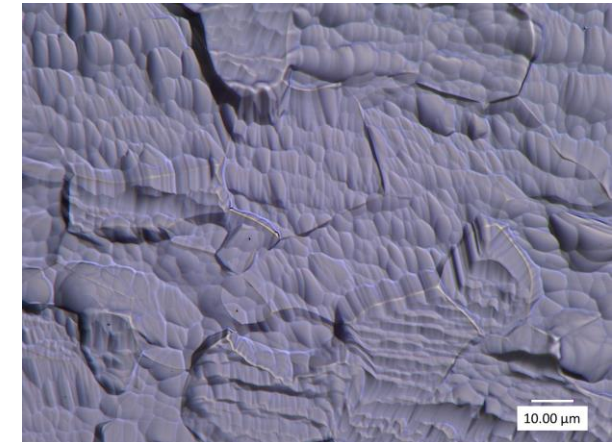


Gibbs free energy of isolated vortex



Single vortex near ideal surface parallel to external field

Optical Image of BCP Nb

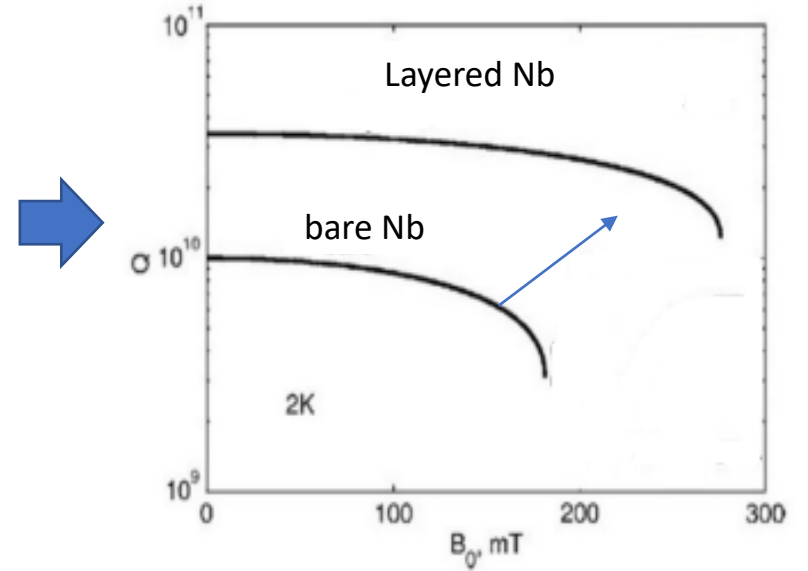
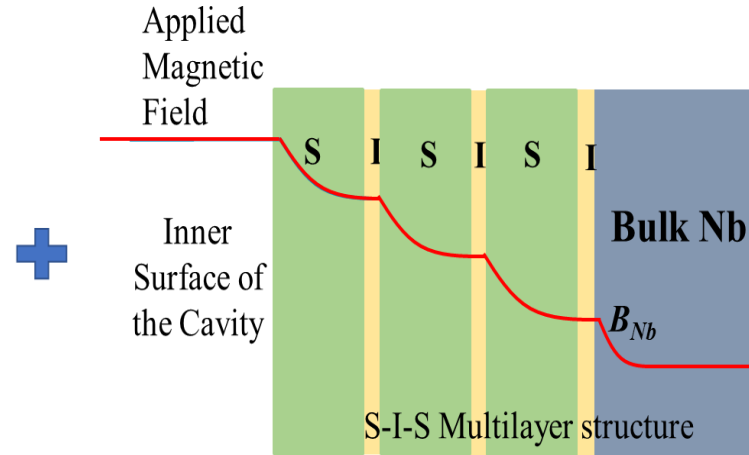


- Vortices have to overcome surface barrier even at $H > H_{c1}$
- Surface barrier vanishes at superheating field H_{sh}
- Surface barrier weakens at defects and vanishes at $H = H_p$
where $H_{c1} < H_p < H_{sh}$ even at $H_p < H_{c1}$
- **Early flux penetration limits the SRF cavity performances at higher fields**

SIS Multilayers on Nb : Shield Nb at high surface magnetic field



Half of the multicell cavity showing inner view

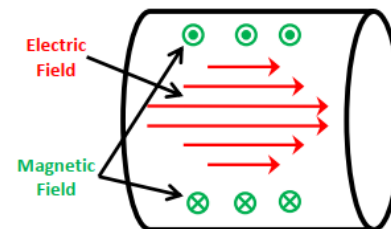


- Nb₃Sn **S**
 - NbN **S**
 - NbTiN
 - Pnictides
 - Alloyed Nb...
- Al₂O₃ **I**
 - MgO **I**
 - AlN...

Thin SC layer ($< \lambda$) $\rightarrow H_p \uparrow$ \rightarrow Vortex enter at higher field
 \rightarrow allows high magnetic field inside the cavity
 \rightarrow Shield Nb surface
 \rightarrow higher E_{acc}

Objective of the project

- **Surface field at onset of flux penetration, B_p** is a useful characteristic to explore the shielding effect of SIS multilayers.
- Techniques to measure the onset of magnetic field penetration into superconducting samples need to be developed emulating the field profile at wall of the SRF cavity operating at fundamental accelerating mode.
- In this project, Magnetic Field Penetration (MFP) Magnetometer was designed, built and then implemented for measurements at Jefferson Lab.

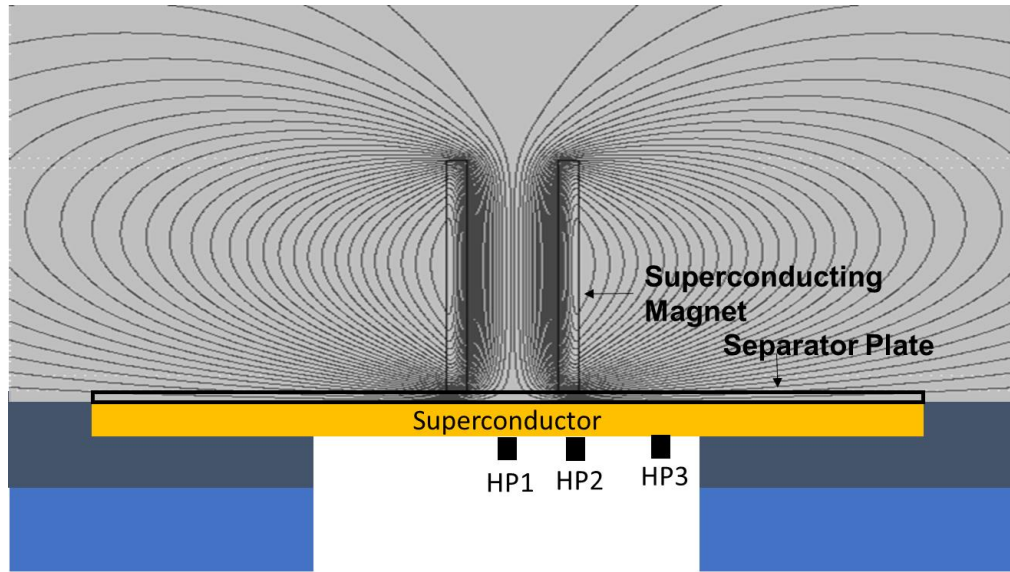


fundamental accelerating mode
 TM_{010} used for acceleration

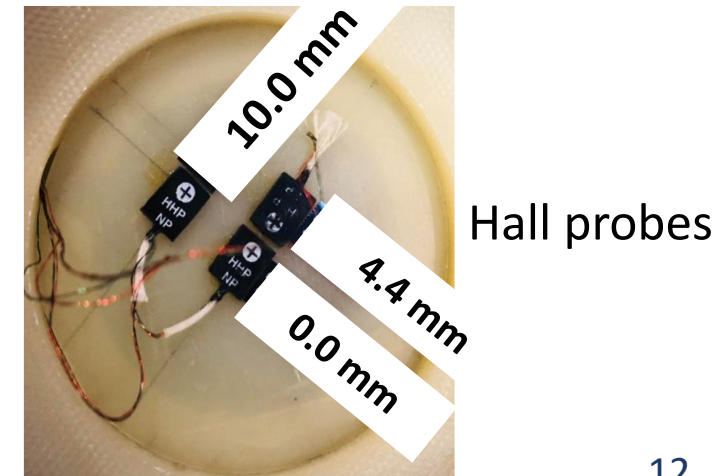
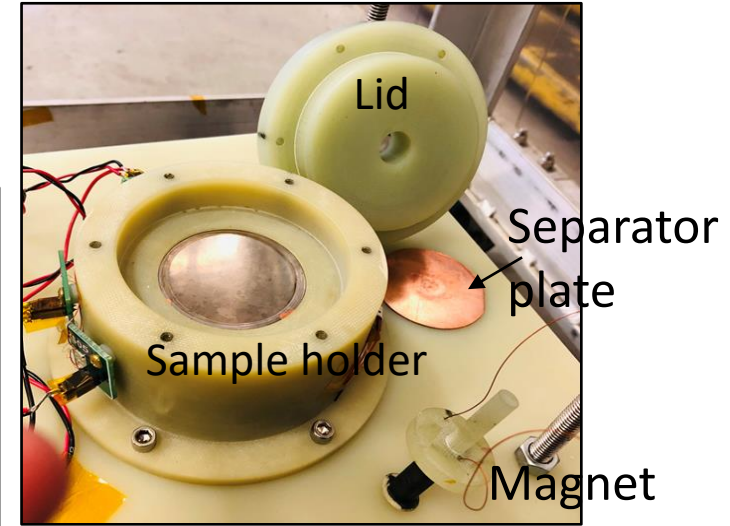
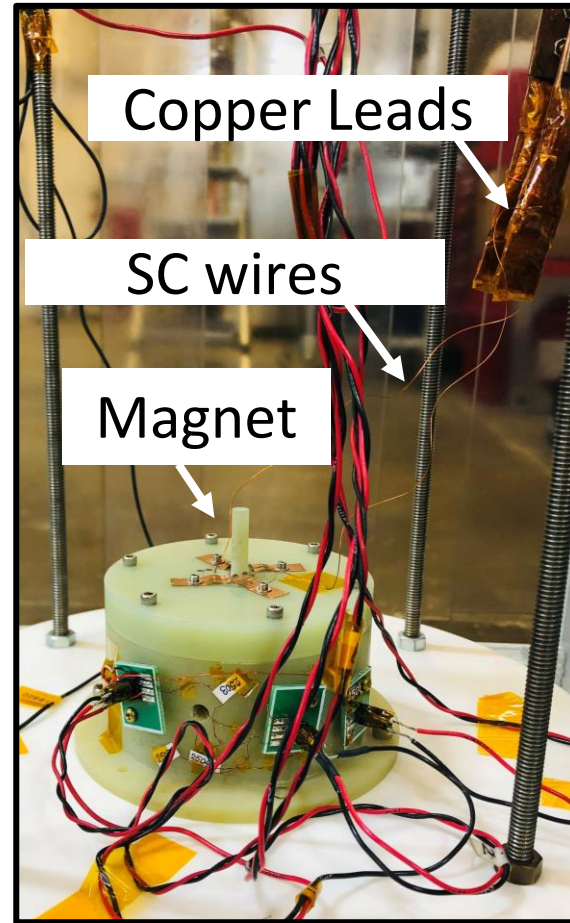
Magnetic Field Penetration (MFP) Magnetometer

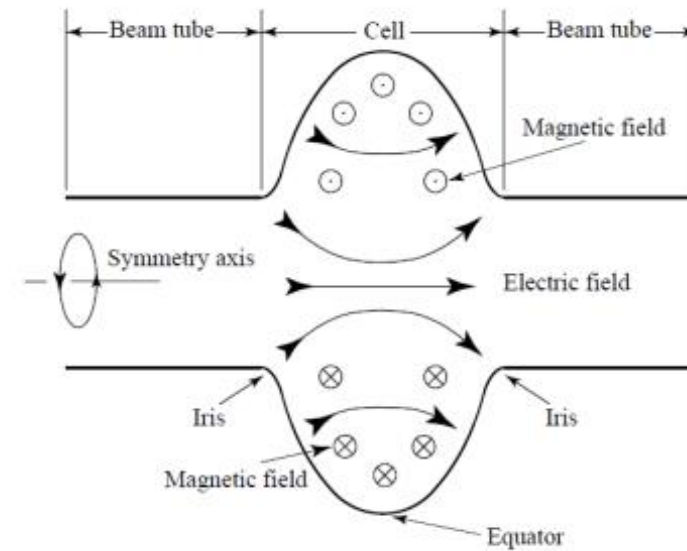
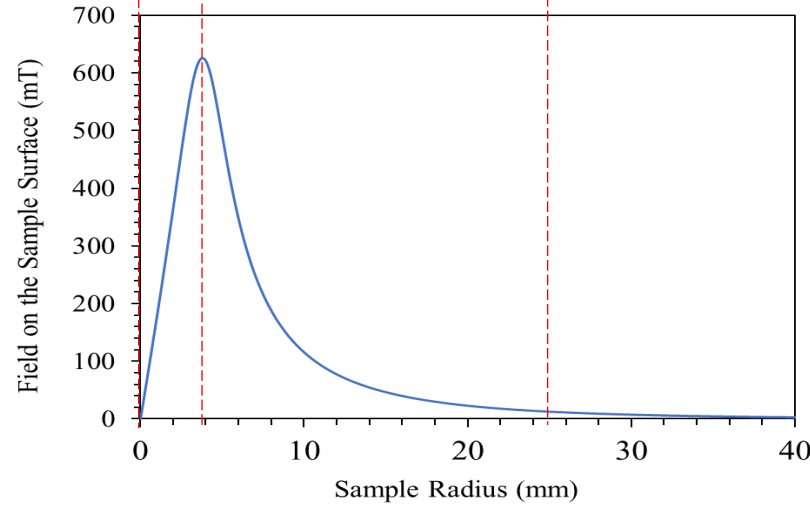
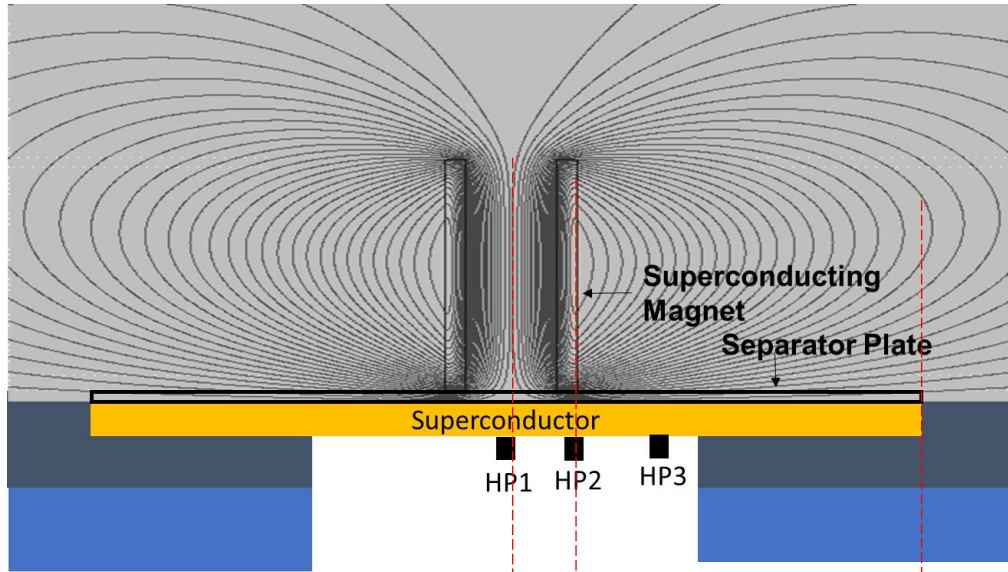


To investigate the shielding effect of multilayers, Magnetic Field Penetration (MFP) magnetometer is designed, built and implementing for magnetic field penetration measurements.

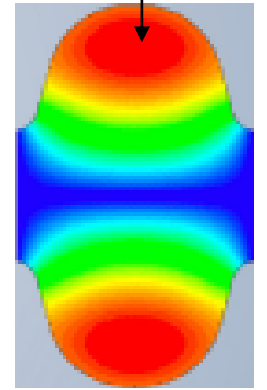


Basic Experimental Setup

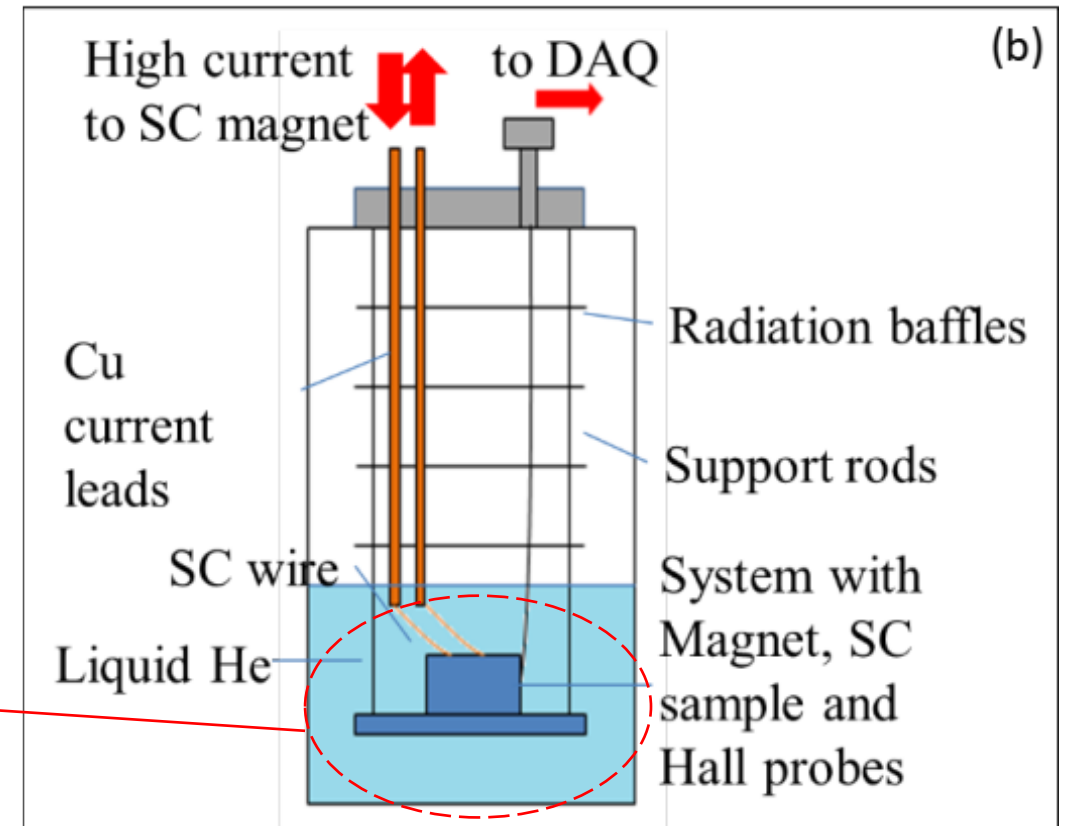
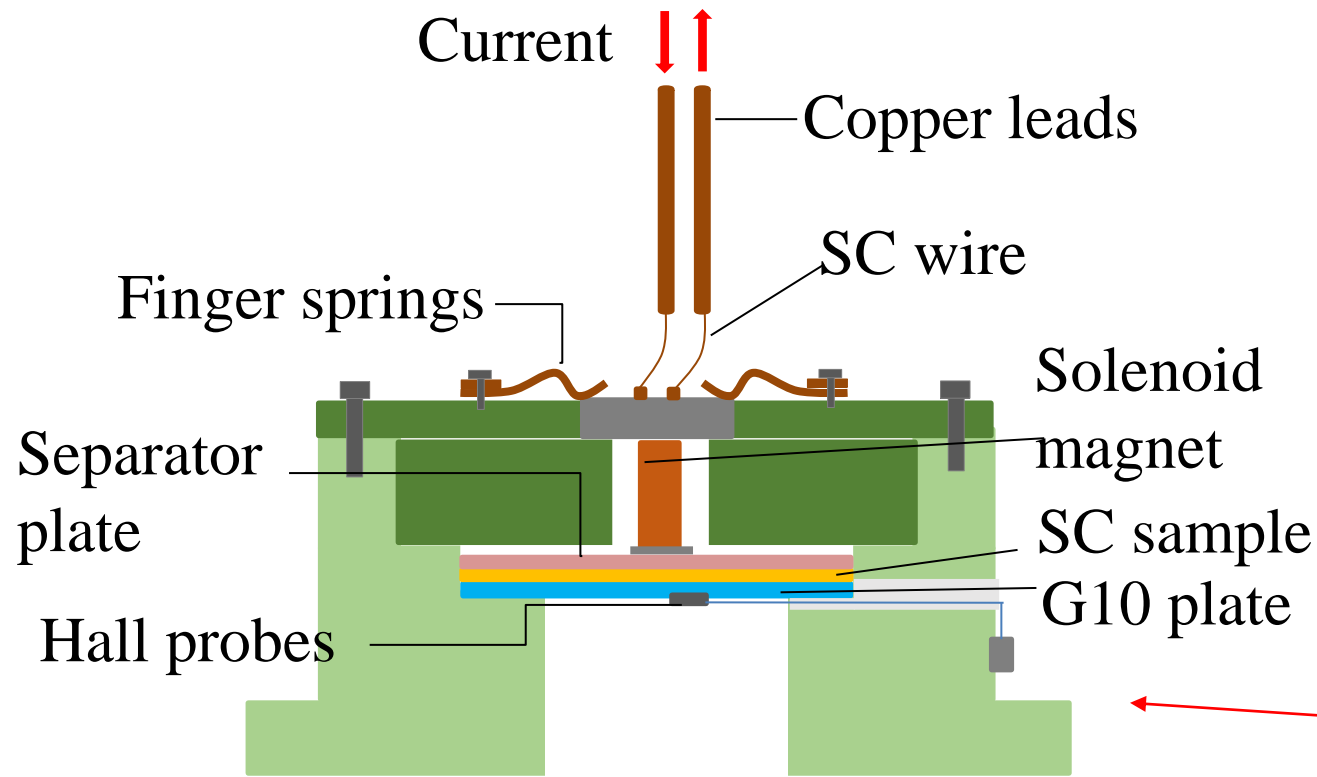




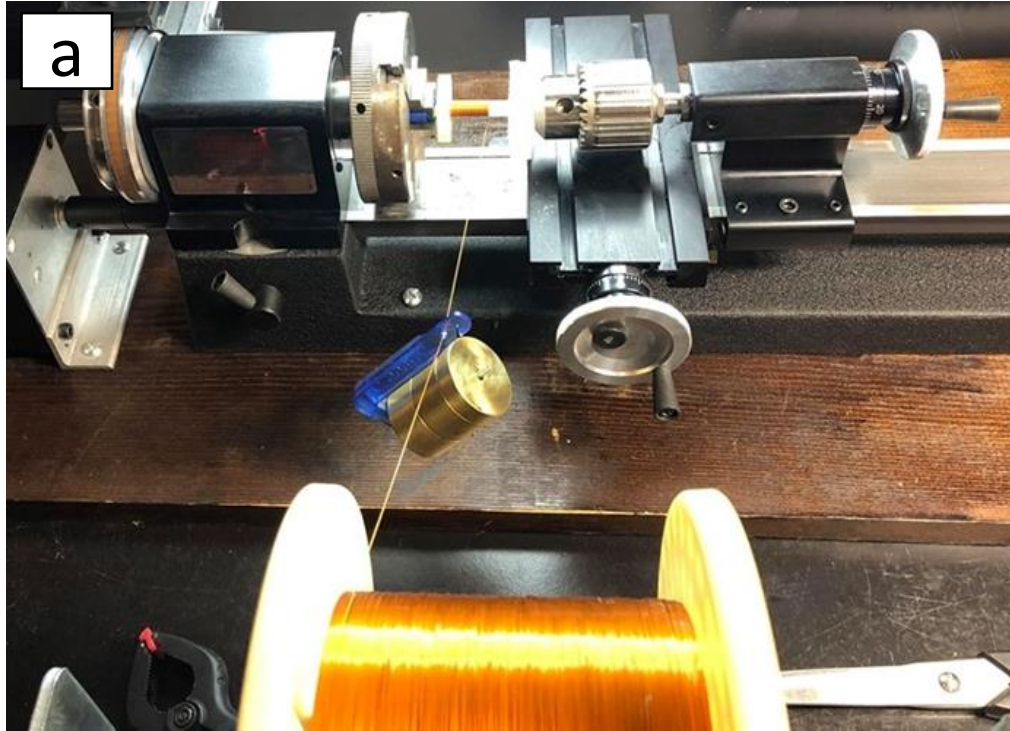
Peak Magnetic field



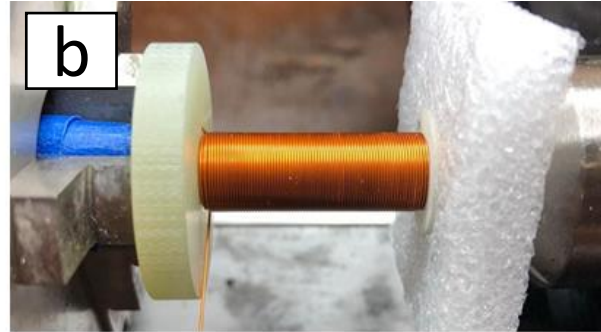
- In the Meissner state, sample act as a magnetic mirror.
- A current is generated at the surface of the superconductor in order to cancel the applied field at the surface.
- The combined applied and induced fields result is parallel to the sample surface, which resembles the magnetic field profile at the equator of the accelerating cavity.



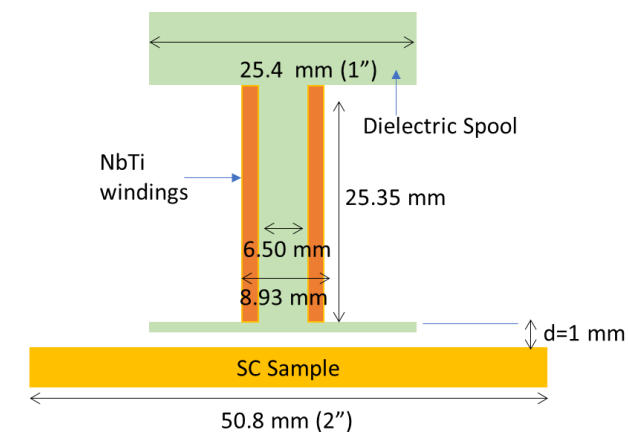
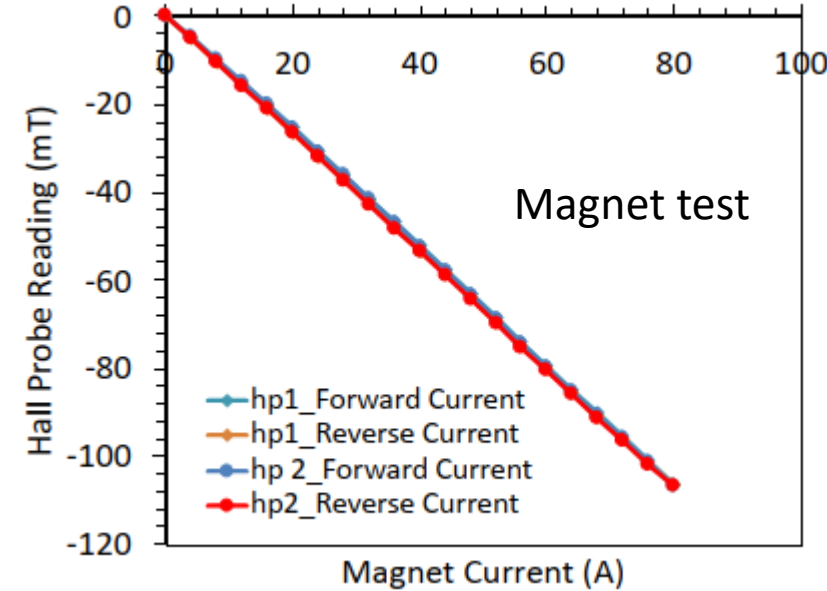
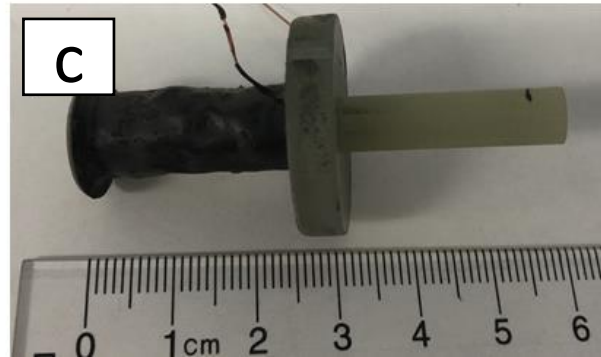
Magnet Fabrication



Magnet winding set up

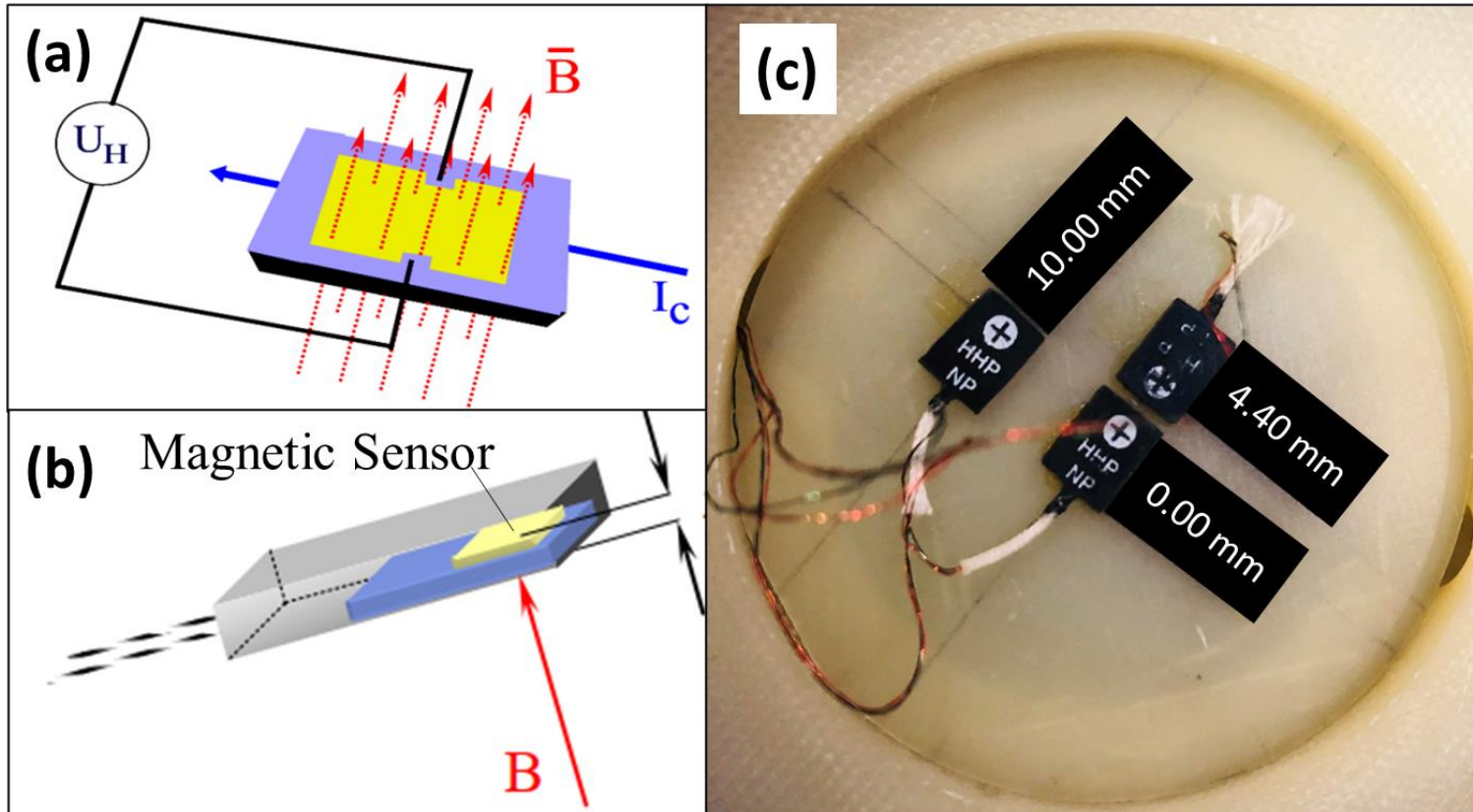


Magnet covered with epoxy



NbTi SC magnet allows to apply high current more than 80 A in order to have high field at the sample surface greater than 500 mT

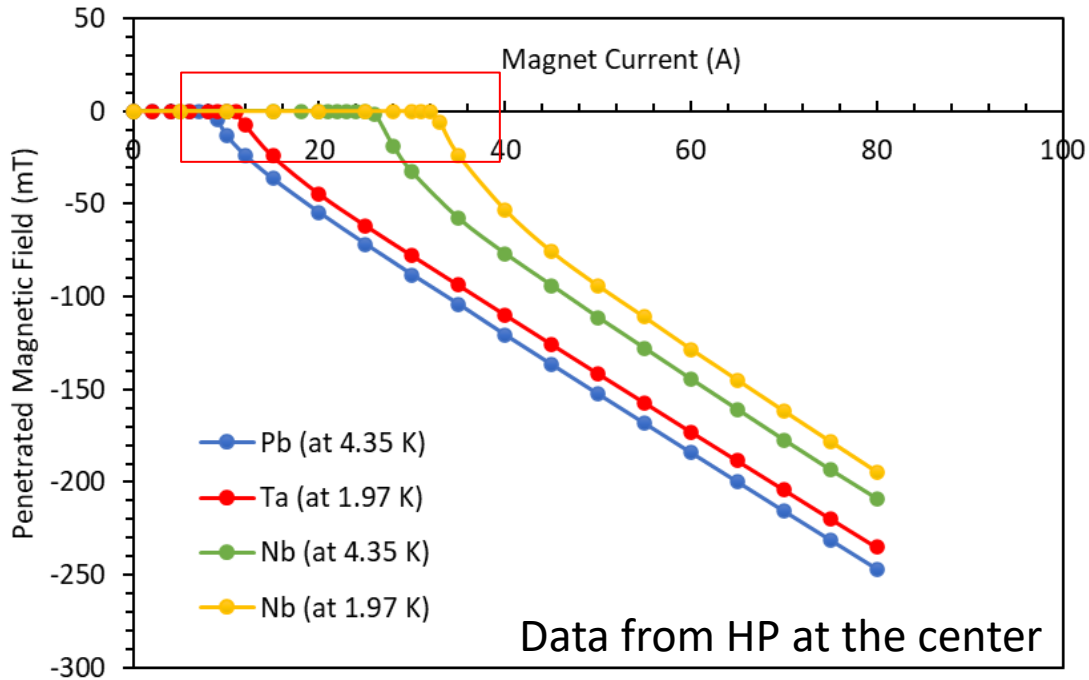
Hall Probes used in the setup



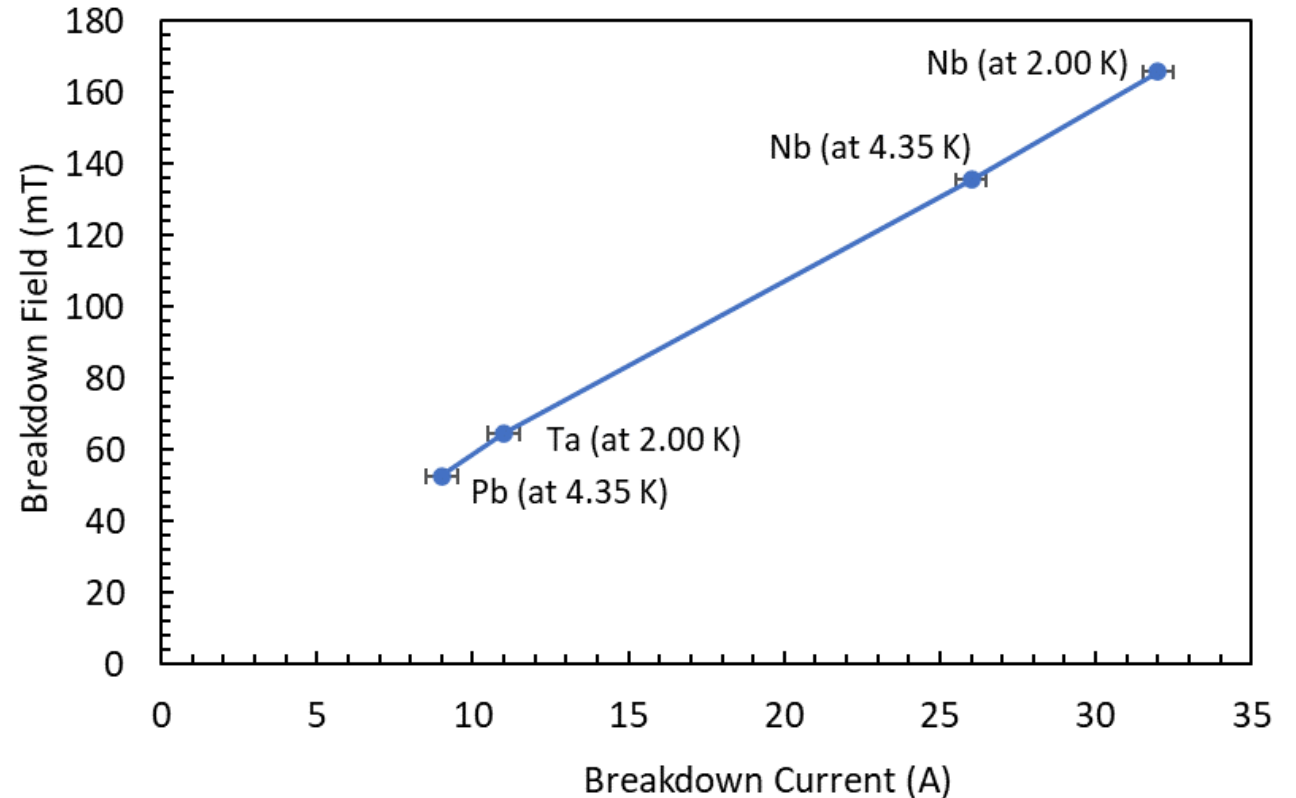
- (a) HHP-NP Hall probes used in the experimental setup that can detect the component of the magnetic field perpendicular to the probe
- (b) the Hall sensor located inside the probe covered with the resin
- (c) configuration of the Hall probes mounted at the bottom of the sample

Setup Calibration: Method 1

Thickness of the samples $\approx 100 \mu\text{m}$



Calibration Curve



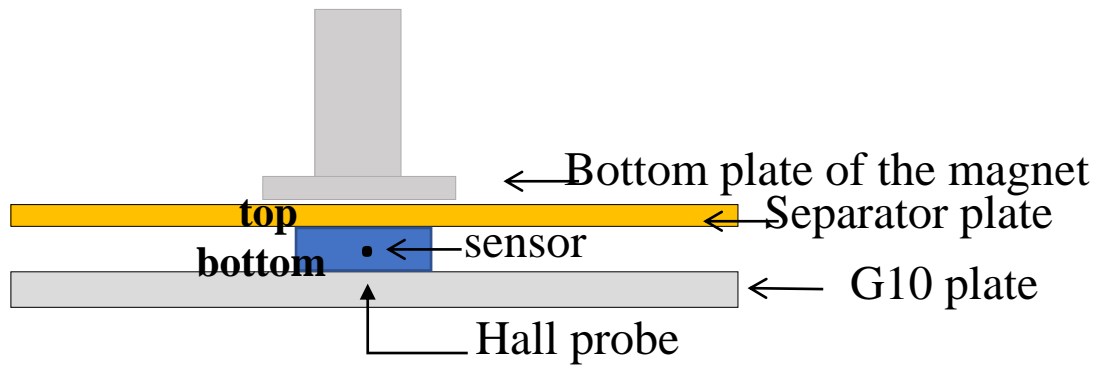
Ref:

- G. Chanin and J. P. Torre, "Critical-field curve of superconducting lead," *Phys. Rev. B* **5**, 4357–4364 (1972).
- D. K. Finnemore, T. F. Stromberg, and C. A. Swenson, "Superconducting properties of high-purity niobium," *Phys. Rev.* **149**, 231–243 (1966)
- C. H. Hinrichs, C. A. Swenson, "Superconducting critical field of tantalum as a function of temperature and pressure", *Phy. Rev.* Vol. 123, No. 4, 1961

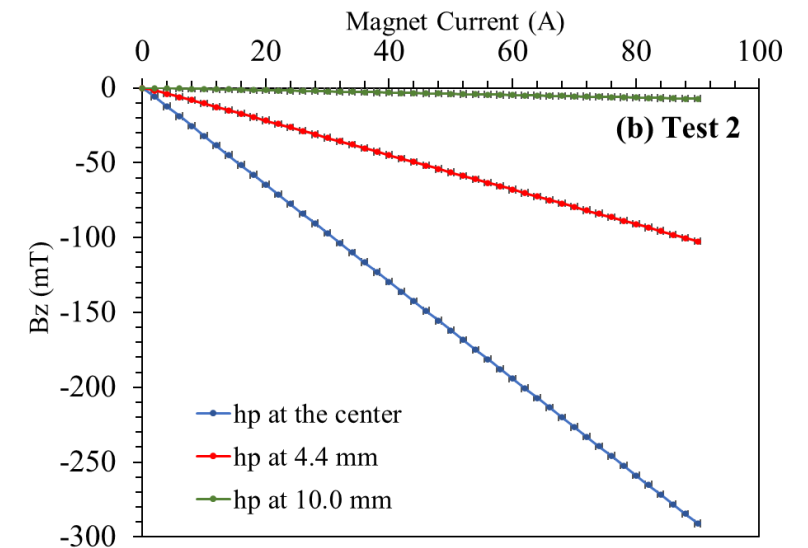
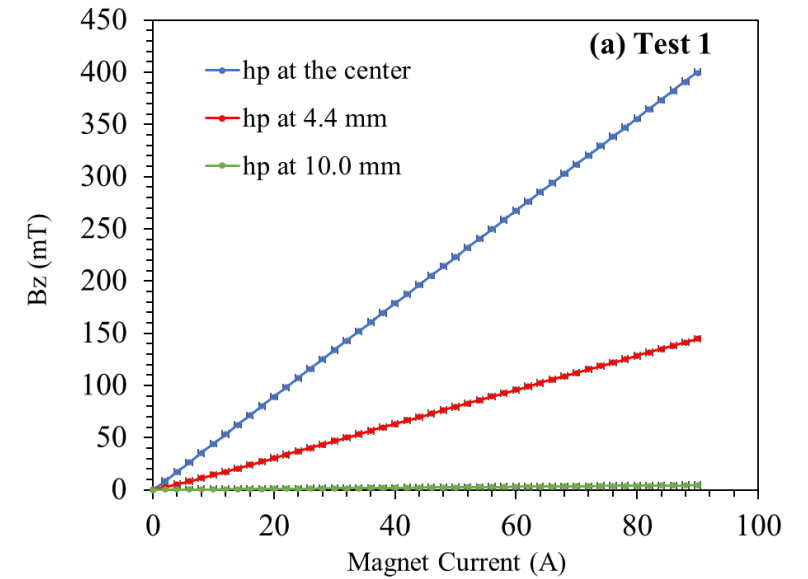
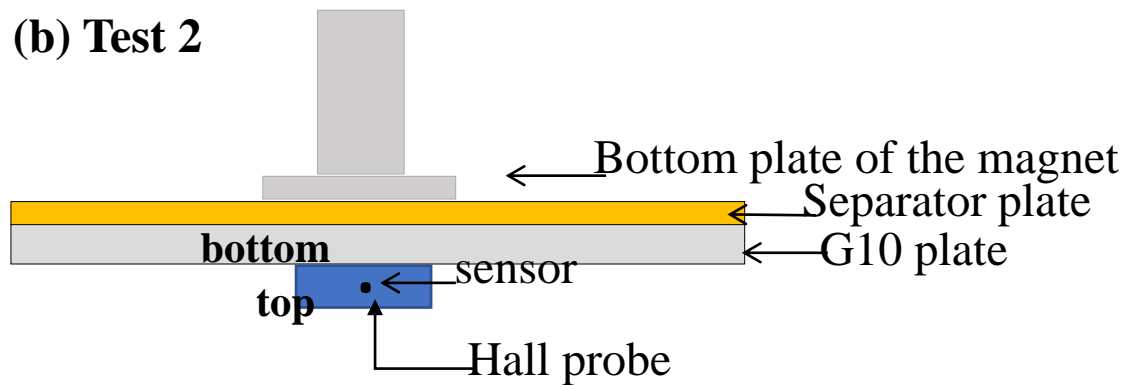
Setup Calibration: Method 2

Measurements of B_z with increasing magnet current

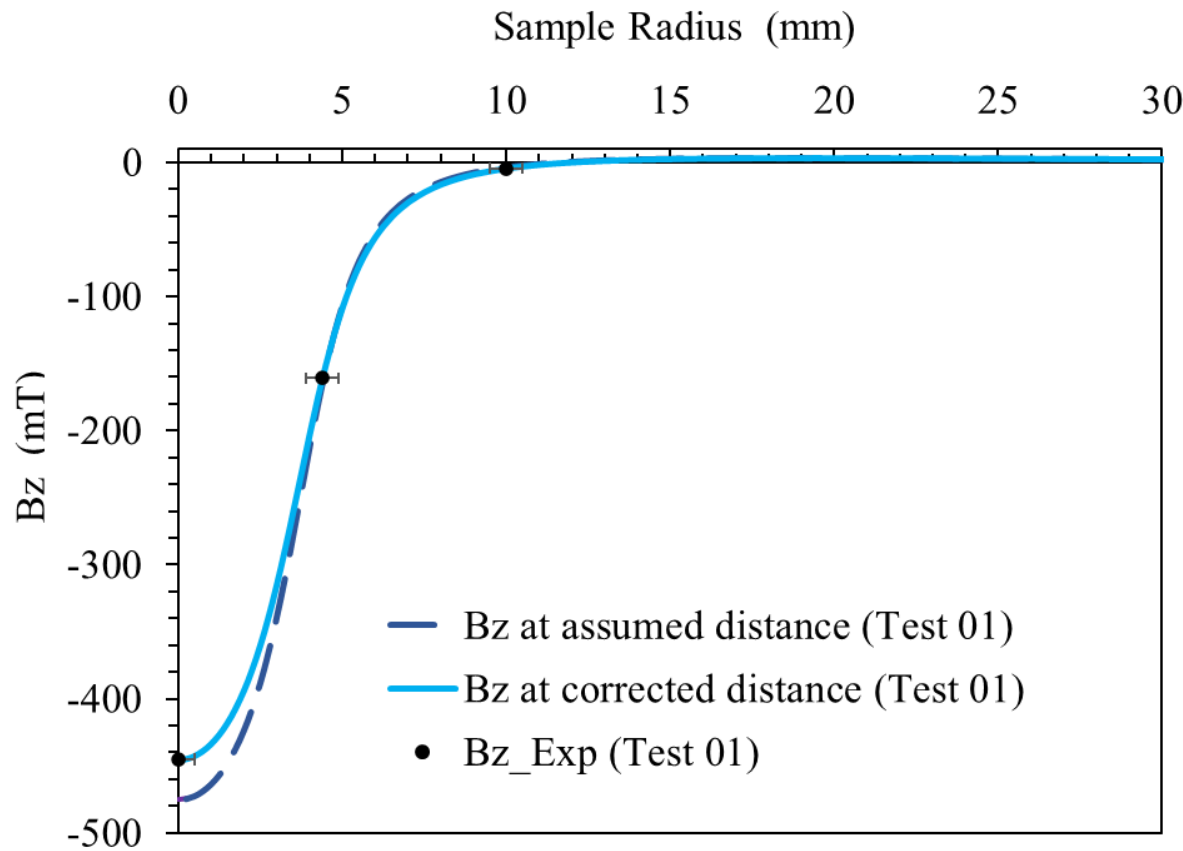
(a) Test 1



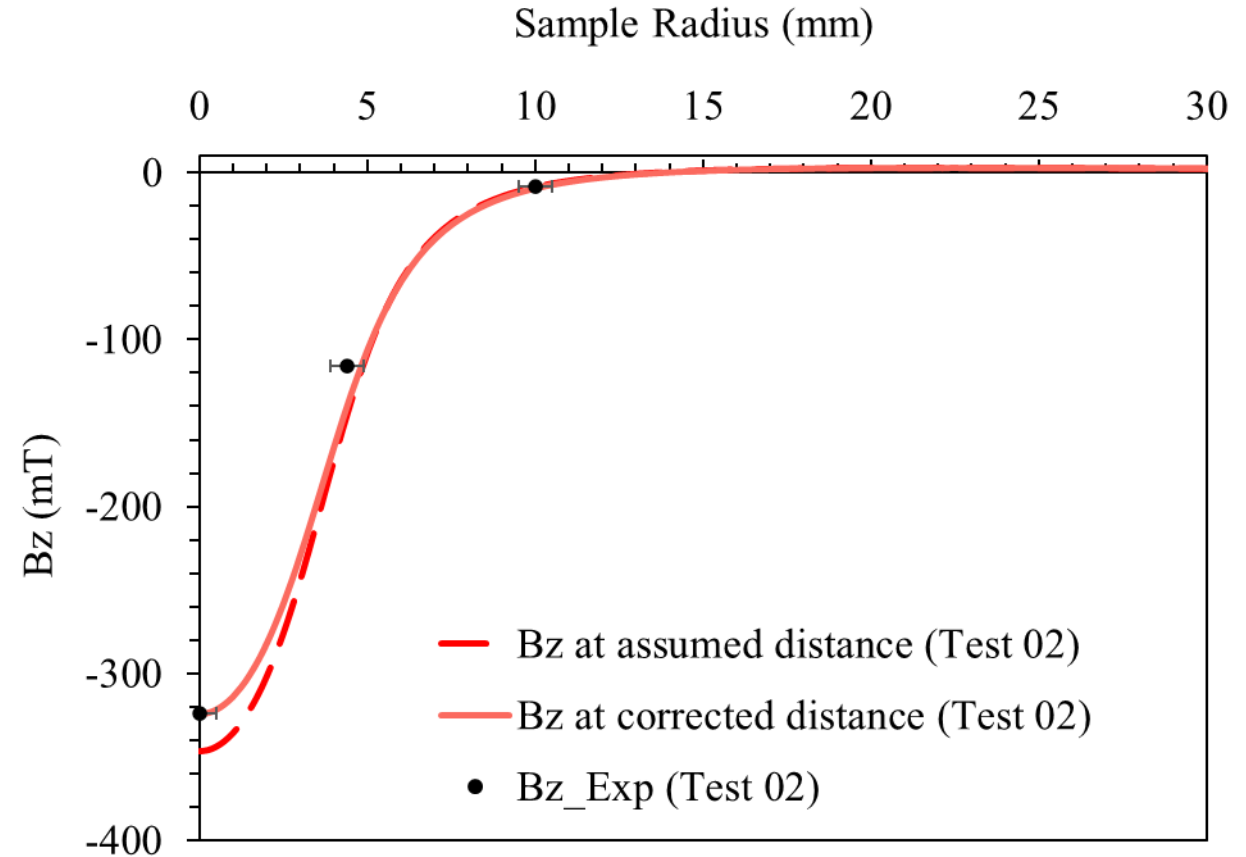
(b) Test 2



Test 01

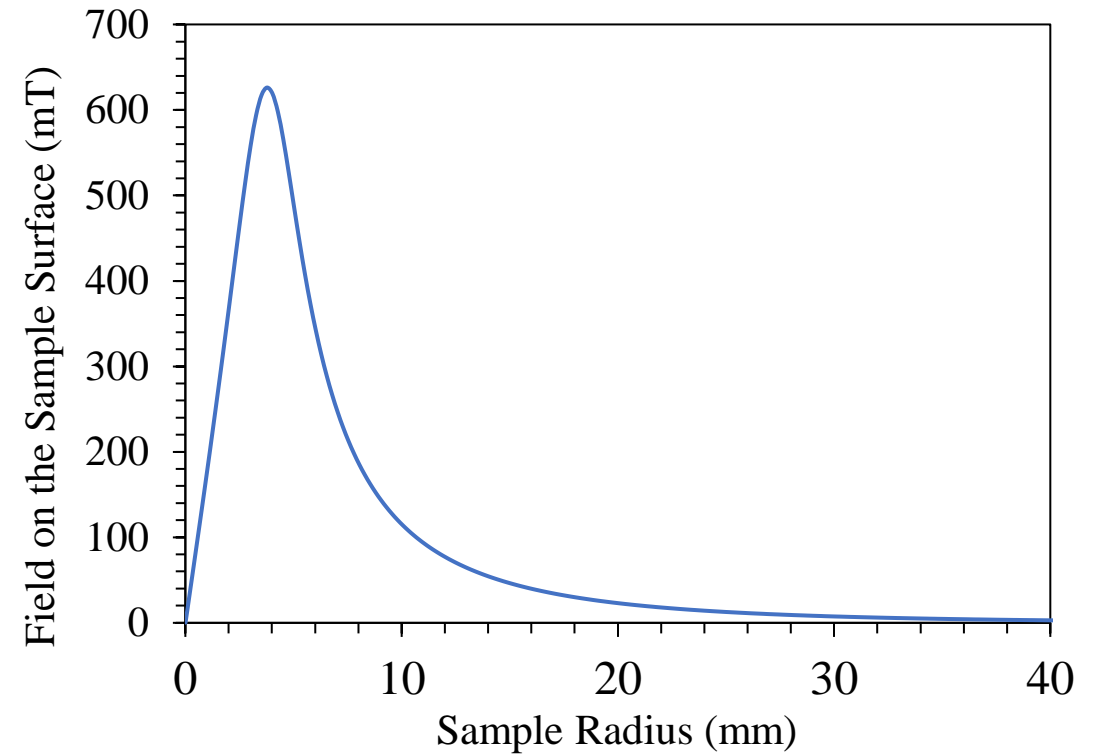
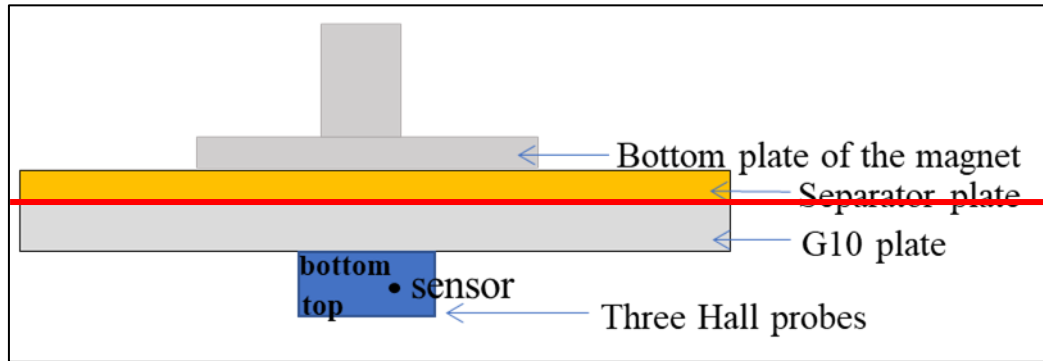


Test 02



Corrected-Assumed = 0.19 mm < less than magnet wire

Calibrated Magnetic field on the surface in Meisnner state at 100 A of current



Corrected separation between magnet and sample surface = $0.992 + 0.19 = 1.182$ mm

Maximum magnetic field at 100 A = 626 mT

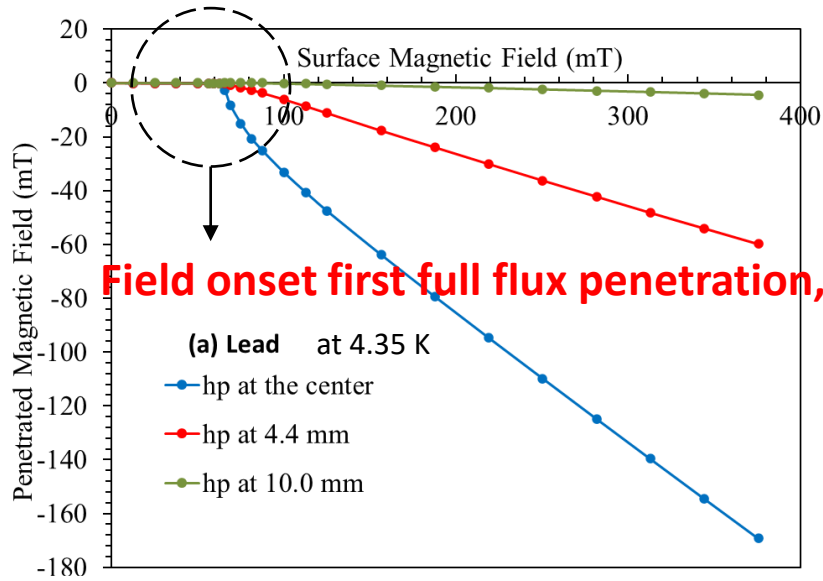
Maximum magnetic field = 6.26 mT/A → Used to current – field conversion, but only valid up to breakdown field

1-Measurements on Bulk Superconductors

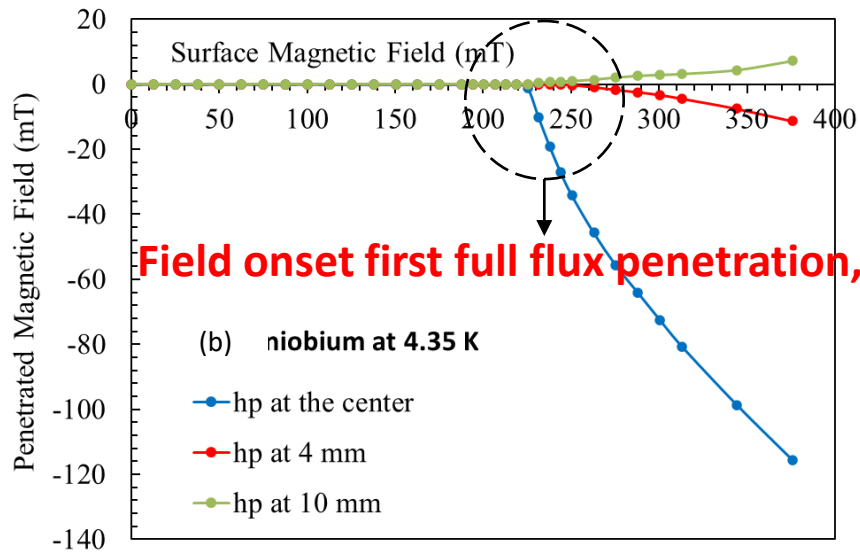


Lead (Pb) and Niobium (Nb)

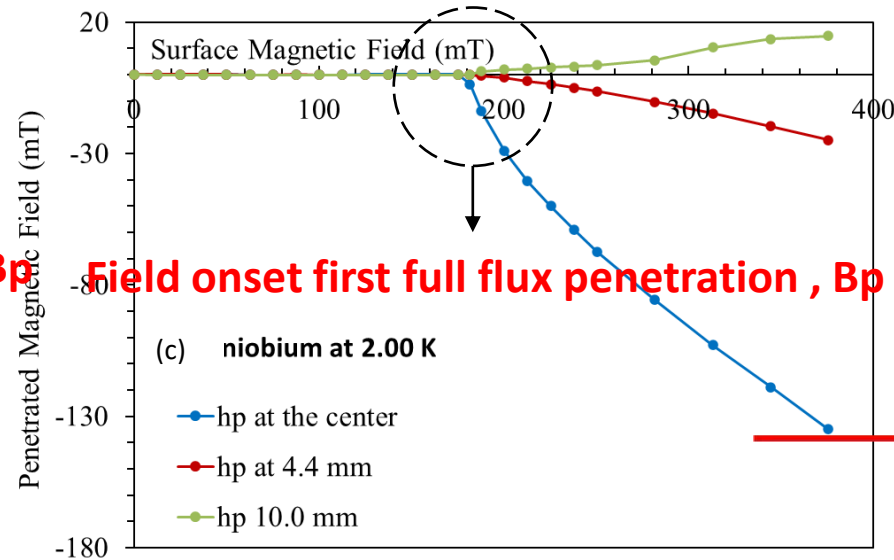
Thickness of the samples $\approx 250 \mu\text{m}$



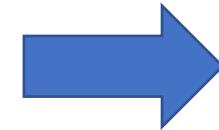
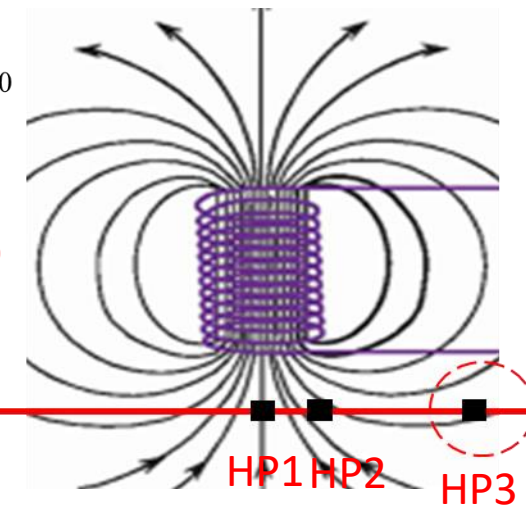
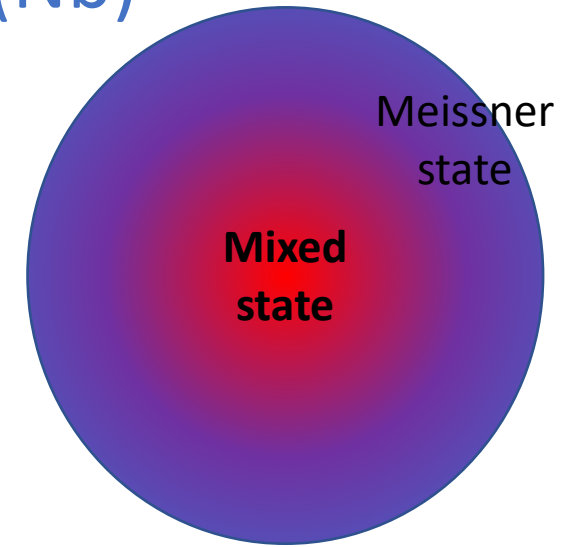
Field onset first full flux penetration, B_p



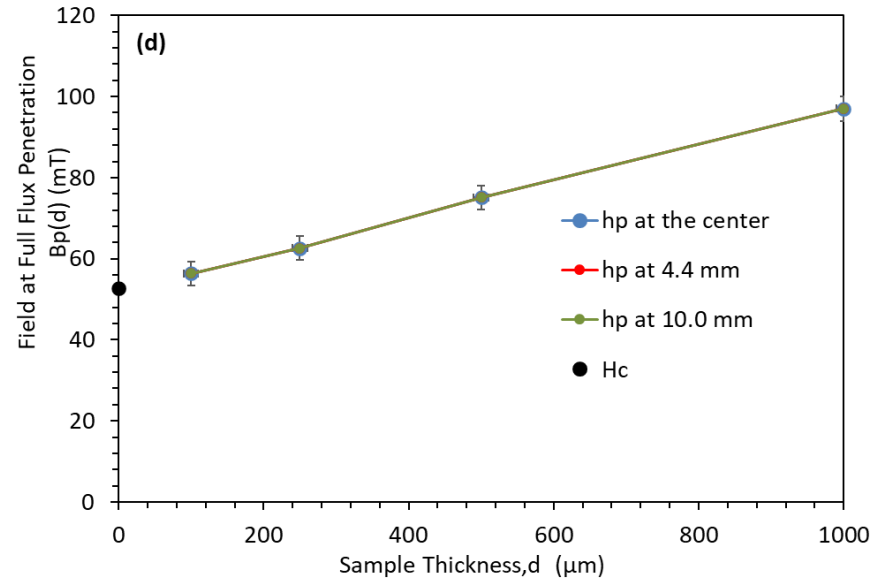
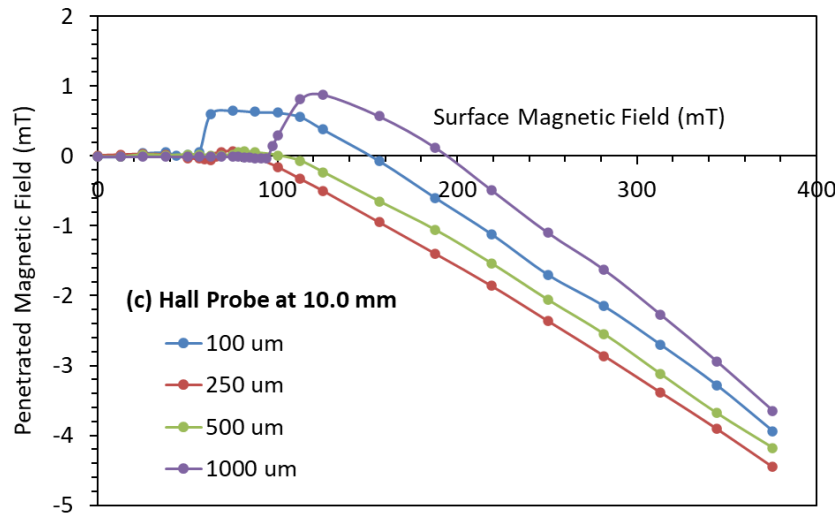
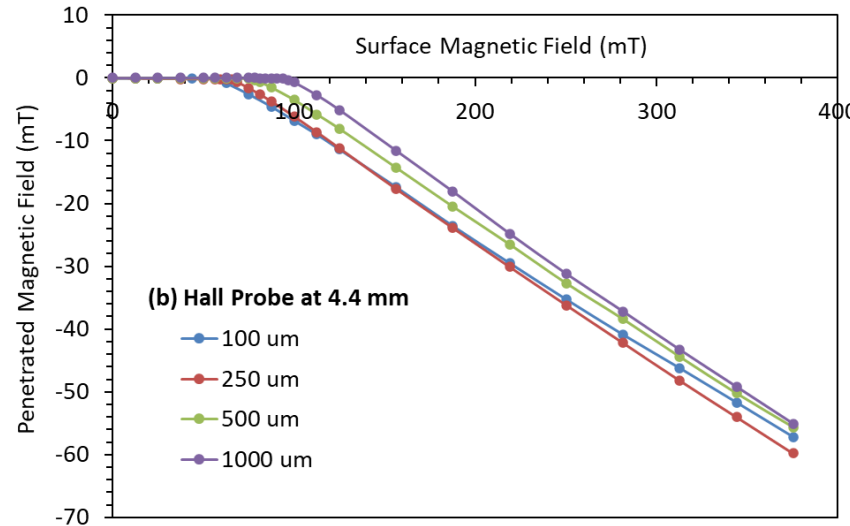
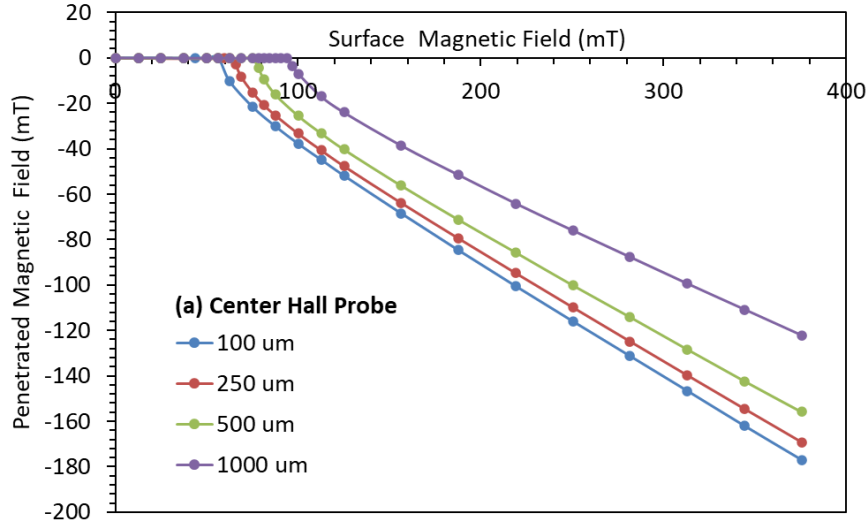
Field onset first full flux penetration, B_p



Field onset first full flux penetration, B_p

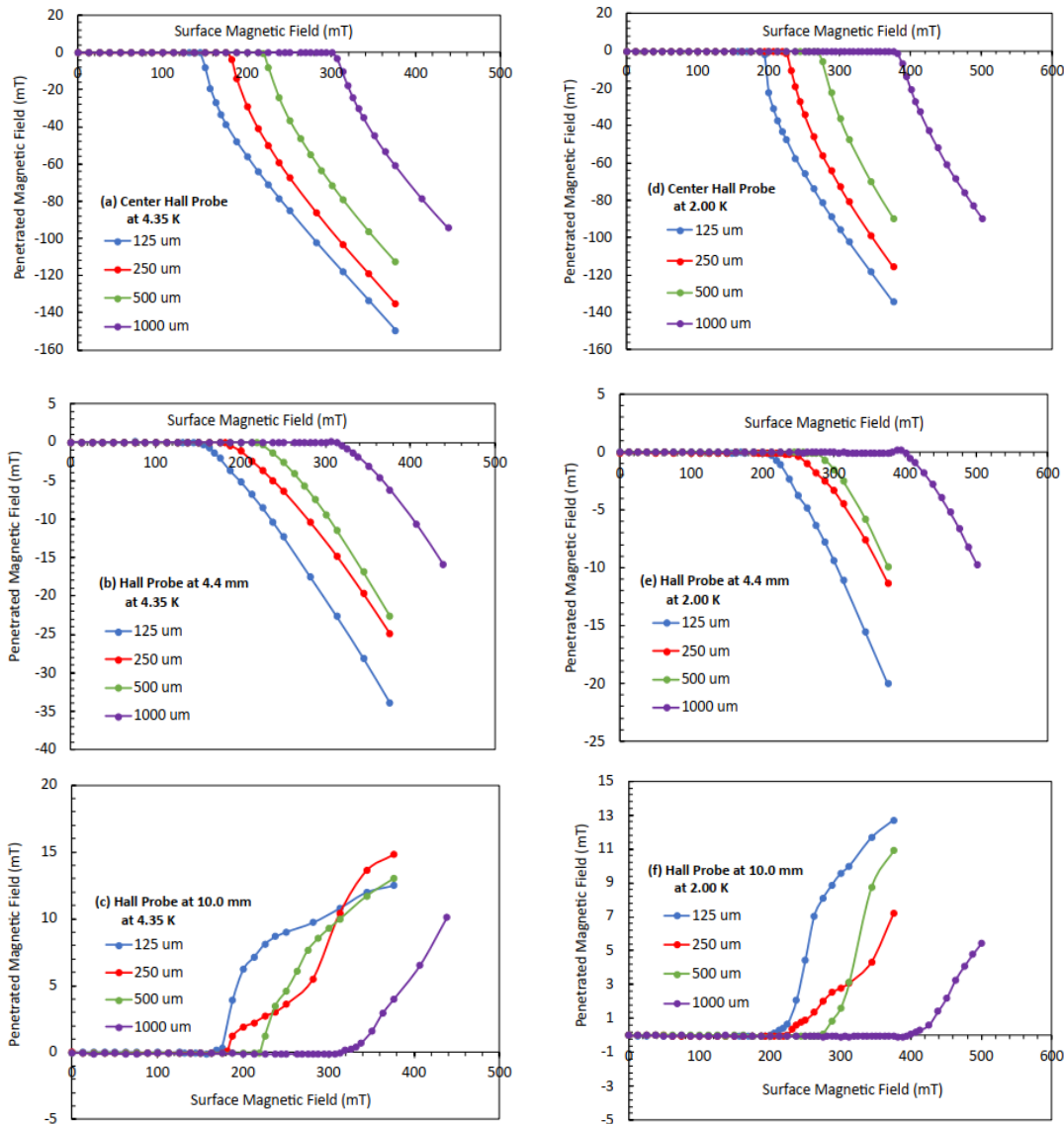


Thickness Effect Lead (Pb) At 4.35 K



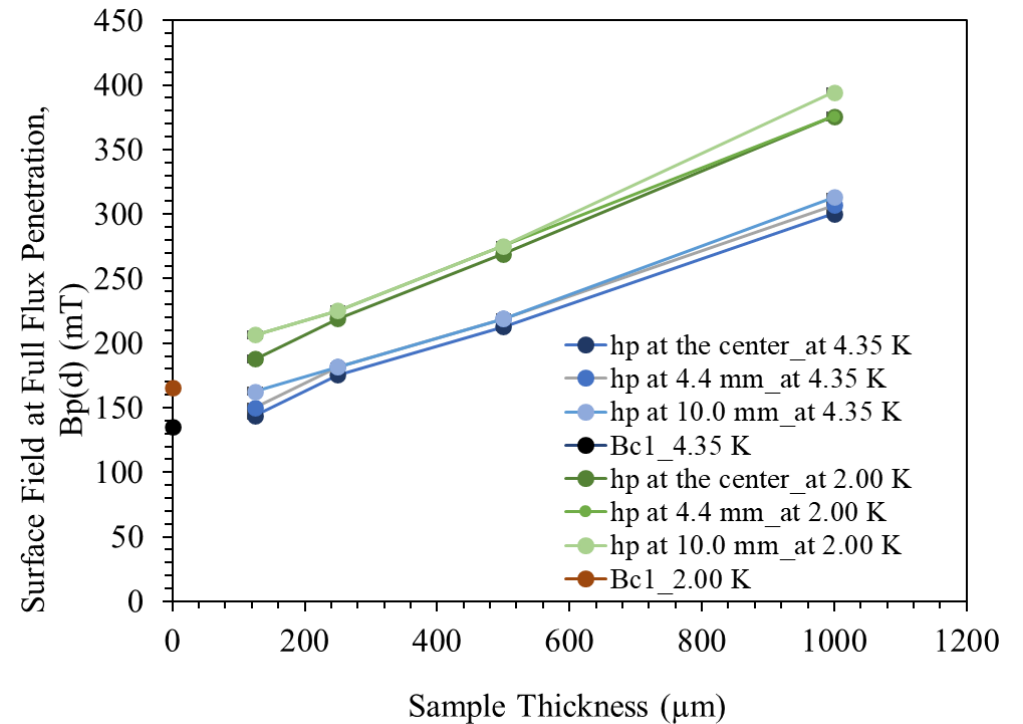
Hc (mT) at 4.35 K	
Extrapolated	51.29
From Ref	52.64

Ref: G. Chanin and J. P. Torre, "Critical-field curve of superconducting lead," *Phys. Rev. B* **5**, 4357–4364 (1972).



Thickness Effect

Niobium (Nb) at 4.35 K and 2.00 K



Hc1 (mT)	4.35 K	2.00 K
Extrapolated	132.54	163.30
From Ref	135.52	165.86

Ref: D. K. Finnemore, T. F. Stromberg, and C. A. Swenson, "Superconducting properties of high-purity niobium," *Phys. Rev.* **149**, 231–243 (1966)

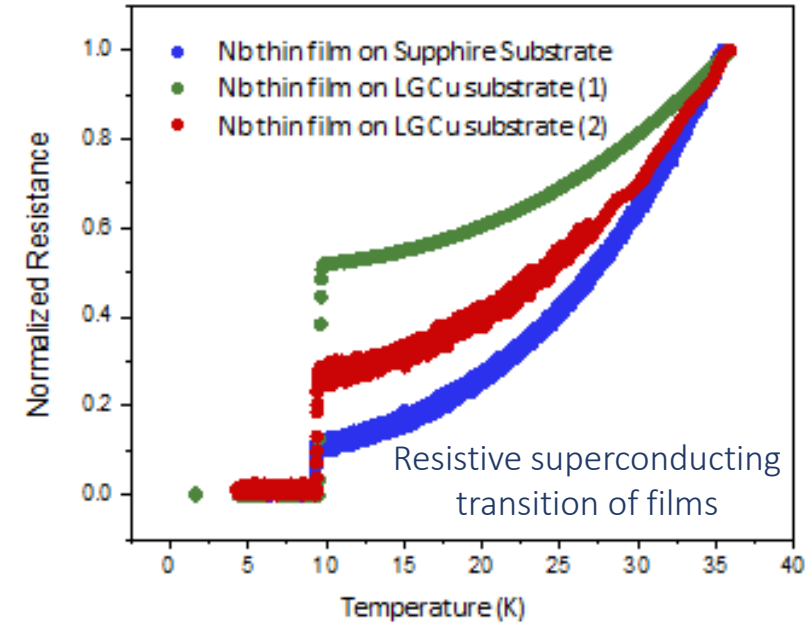
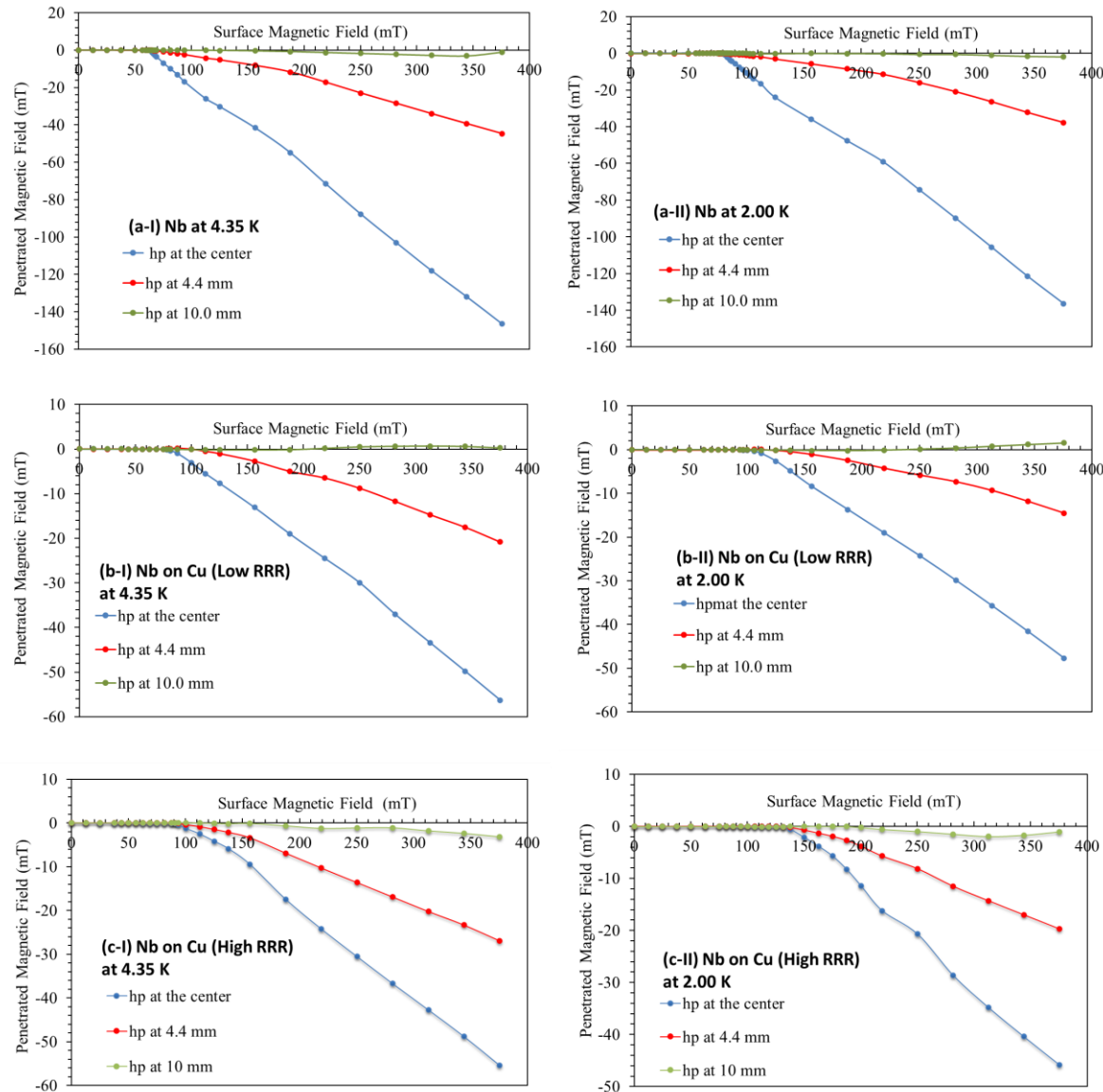


Conclusions

- MFP Magnetometer has been developed to detect the field onset of magnetic flux penetration, B_p through flat samples of SRF materials.
- Testing the setup on Pb and Nb bulk samples was successful. The variation of B_p is linear with the thickness of sample and it has reproduced the well-known values of critical magnetic fields of these materials.

2-Measurements on Thin Film Superconductors

Magnetic Field Penetration Measurements on Nb thin film by Electron Cyclotron Resonance (ECR) at Jefferson Lab.
 Thickness of the films ~1-3 μm

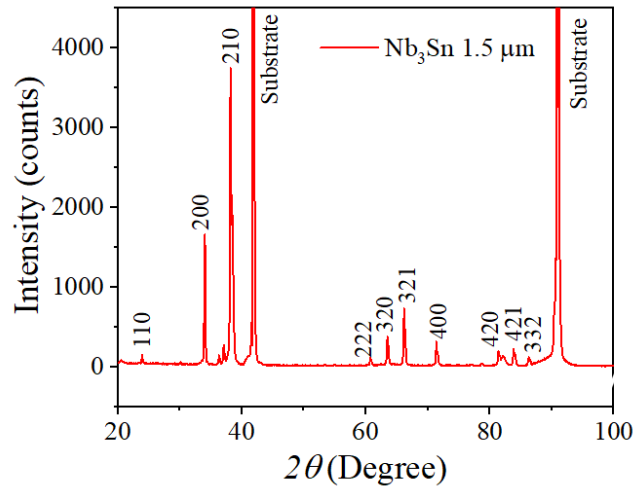


Sample	RRR	Tc	ΔTc	Bp (mT)	
				4.35 K	2.00 K
Nb on Sapphire	332	9.31	0.03	62.6	80.1
Nb on LGCu (1)	34	9.57	0.28	78.3	97.0
Nb on LGCu (2)	190	9.47	0.24	90.8	125.2

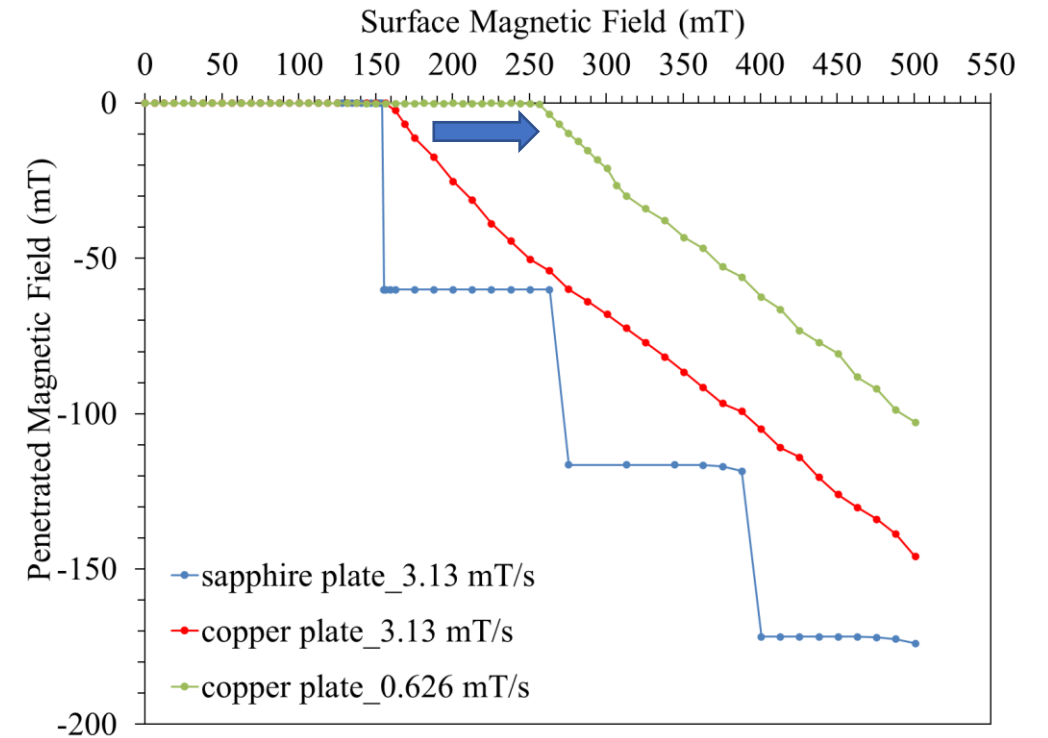
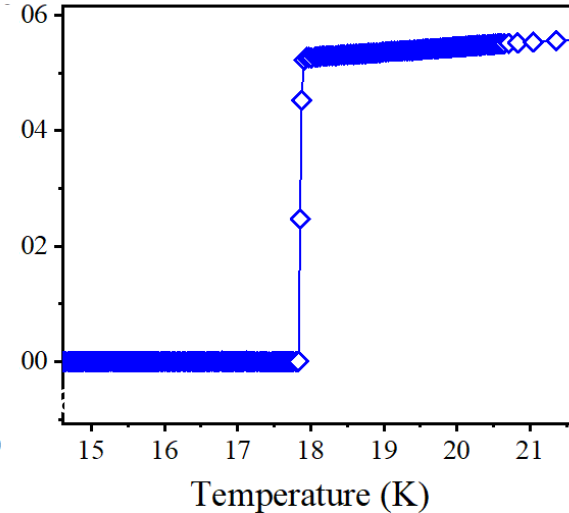
1.5 μm thick **Nb₃Sn thin film** grown on sapphire wafer by multilayer sequential sputtering at room temperature and annealed at 950 °C at Jefferson Lab.

Nb ₃ Sn Critical Fields	
H _{c1} (4.35 K) mT	36
H _{sh} (4.35 K) mT	414

XRD Analysis

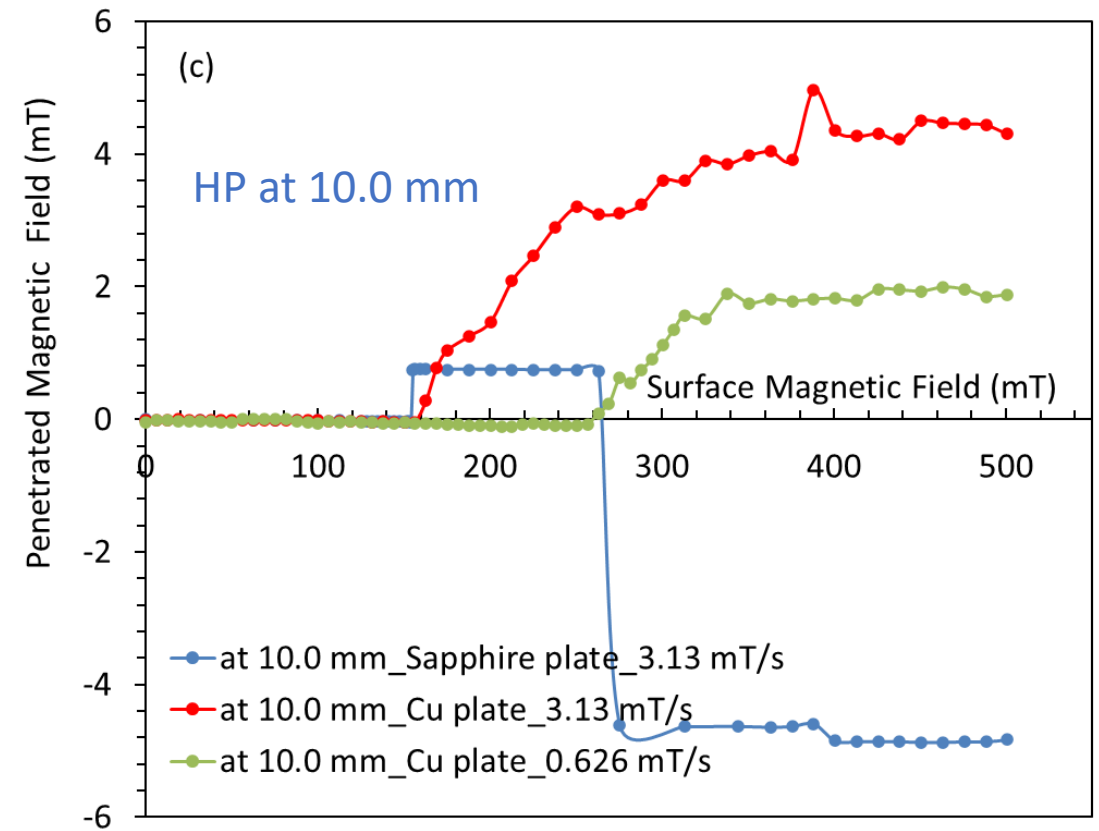
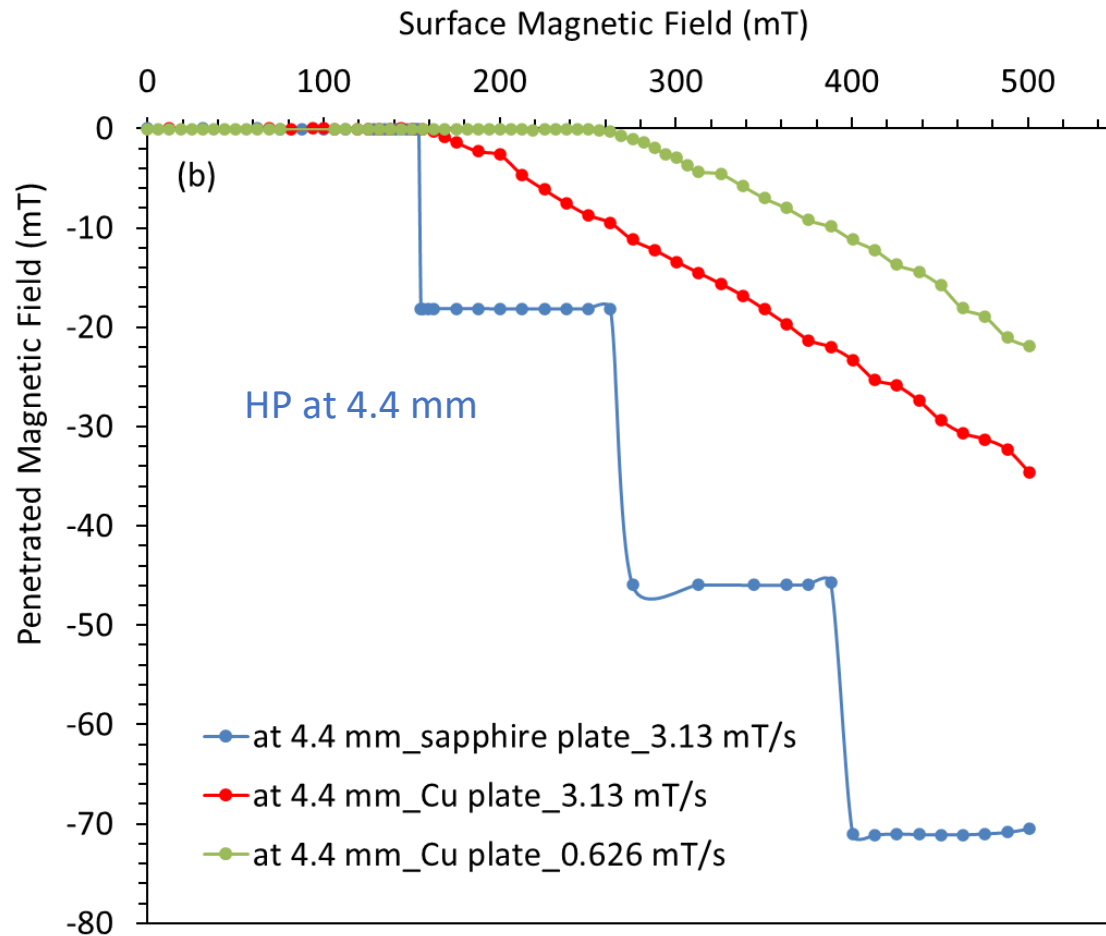


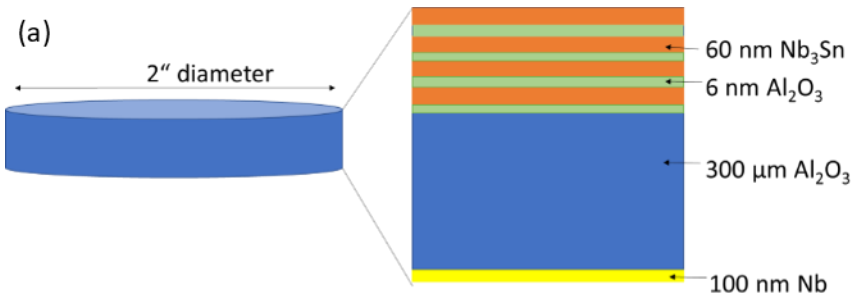
Resistive superconducting transition of film



Field penetration measurements at 4.35 K

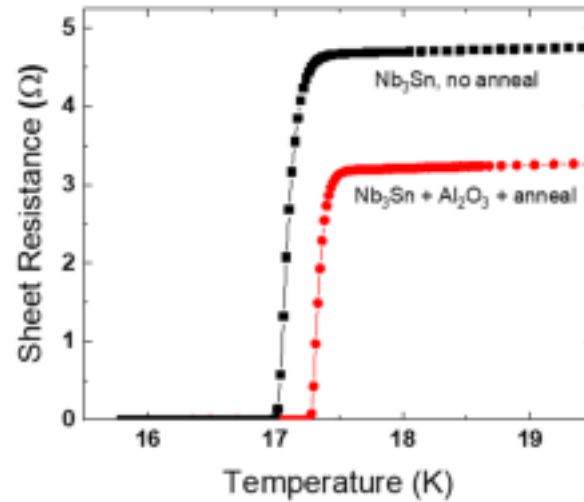
Field penetration measurements from Hall Probe at 4.4 mm and 10.0 mm at 4.35 K on 1.5 μm thick Nb_3Sn thin film grown on Al_2O_3 wafer by multilayer sequential sputtering at room temperature and annealed at 950 $^\circ\text{C}$ at Jefferson Lab.



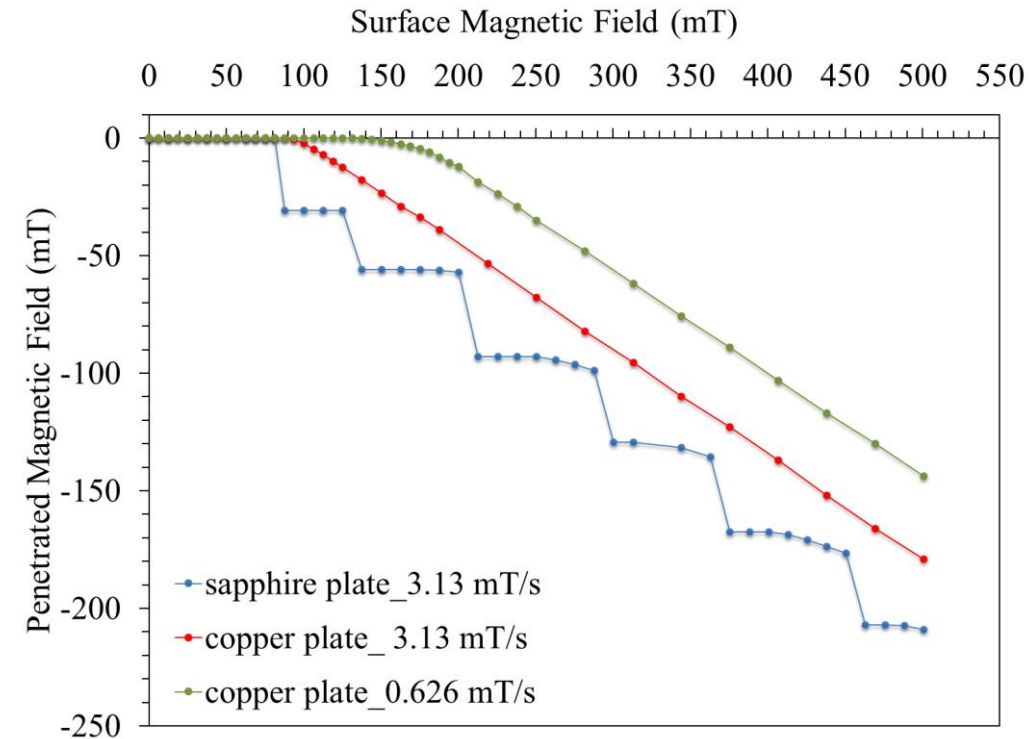


Schematic of Nb₃Sn/Al₂O₃ multilayer heterostructures on Al₂O₃ wafer. Back side of Al₂O₃ wafer is coated with a thick Nb film.

Nb₃Sn/Al₂O₃ multilayer grown on sapphire wafer by high-temperature confocal sputtering at the University of Wisconsin-Madison. This multilayer sample consists of four 60 nm Nb₃Sn layers separated by 6 nm Al₂O₃ interlayers.



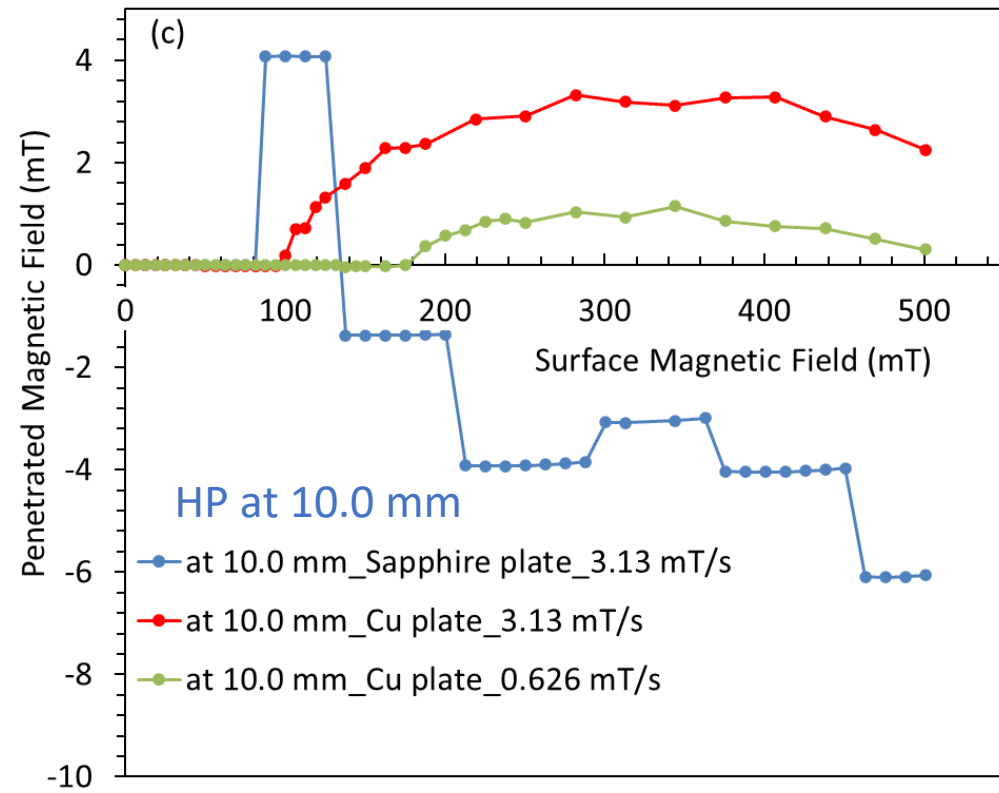
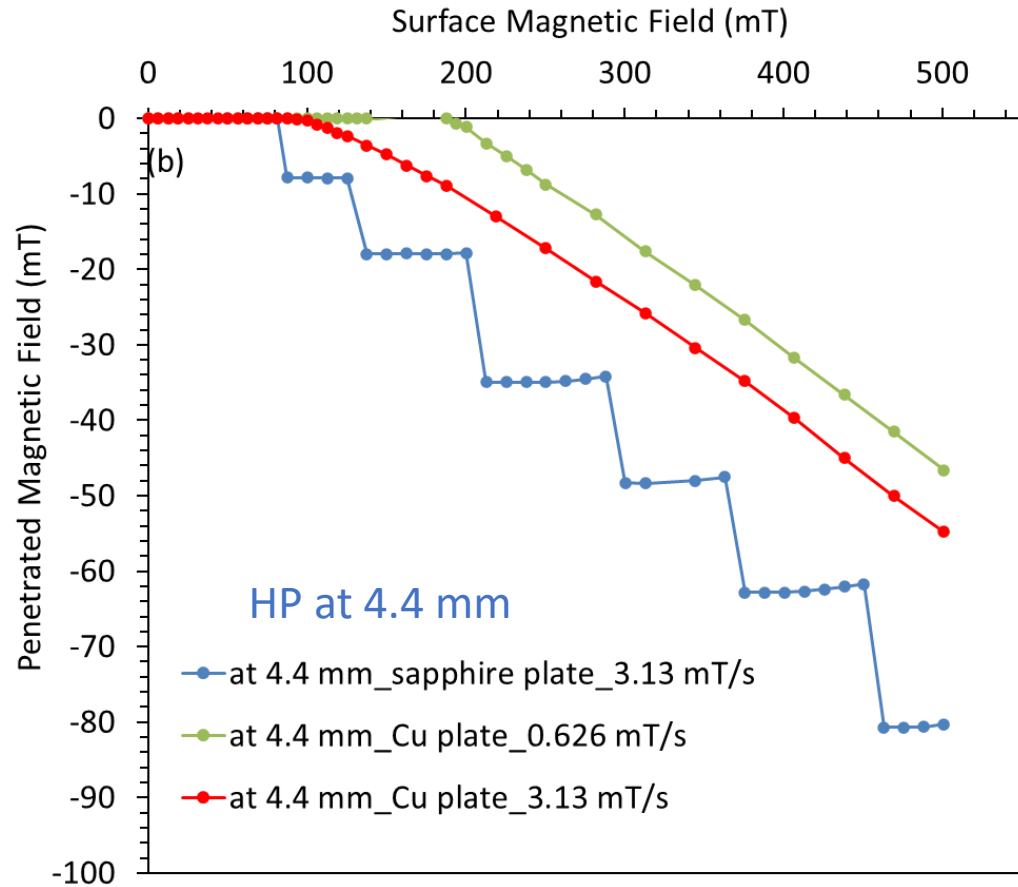
Resistive superconducting transition



Magnetic Field Penetration Measurements

Sundahl *et al*, *Sci. Rep.* **11**, 7770 (2021)

Magnetic Field Penetration Measurements **Hall Probe at 4.4 mm and 10.0 mm** at 4.35 K on Nb₃Sn/Al₂O₃ multilayer grown on Al₂O₃ wafer by high-temperature confocal sputtering at the University of Wisconsin-Madison. This multilayer sample consists of four 60 nm Nb₃Sn layers separated by 6 nm Al₂O₃ interlayers.

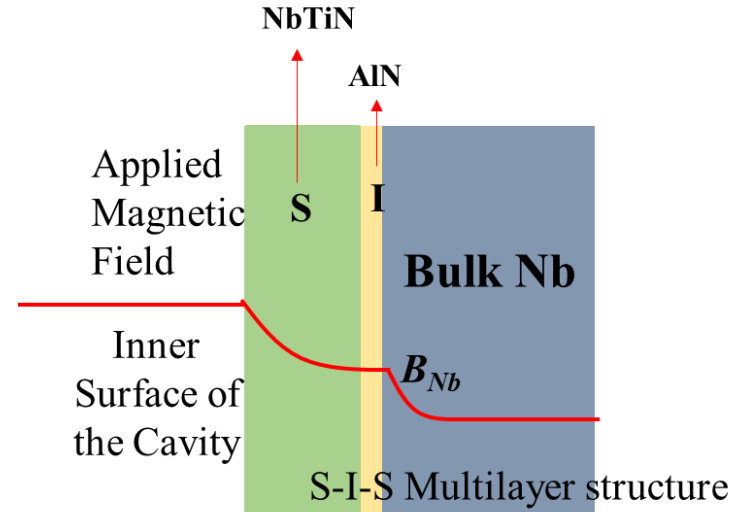


Conclusions

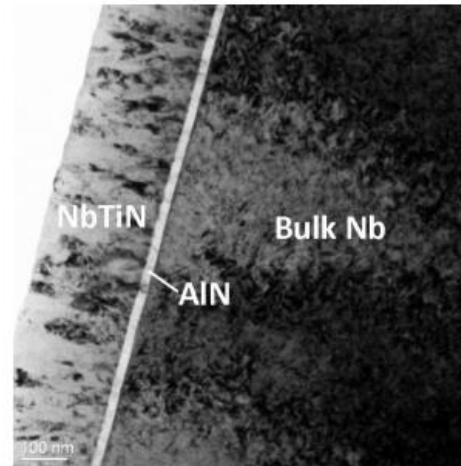
- Thin film measurements of B_p using MFP magnetometer was successful and this is a nondestructive technique for thin film measurements.
- The dependent of B_p with material purity was observed using Nb thin films coated on Cu substrates.
- Low conductive thin film materials, such as Nb_3Sn films, and multilayers exhibit flux jumps due to thermomagnetic flux avalanches. These flux jumps were mitigated by improving heat transfer across the sample and slowing down the magnet ramp rate.

3-Measurements on Multilayered Niobium

- NbTiN and AlN thin layers are deposited on bulk Nb using reactive Direct Current Magnetron Sputtering (reDCMS) in an Ultra-High Vacuum (UHV) system with a base pressure of 10^{-10} Torr.
- The Nb substrates are prepared by buffered chemical polishing (BCP) removing 5 μ m from the surface.
- The films were deposited at 450 °C on bulk Nb after a 24 hour bake at 600 °C, then post-annealed at 450 °C for 4 hours.



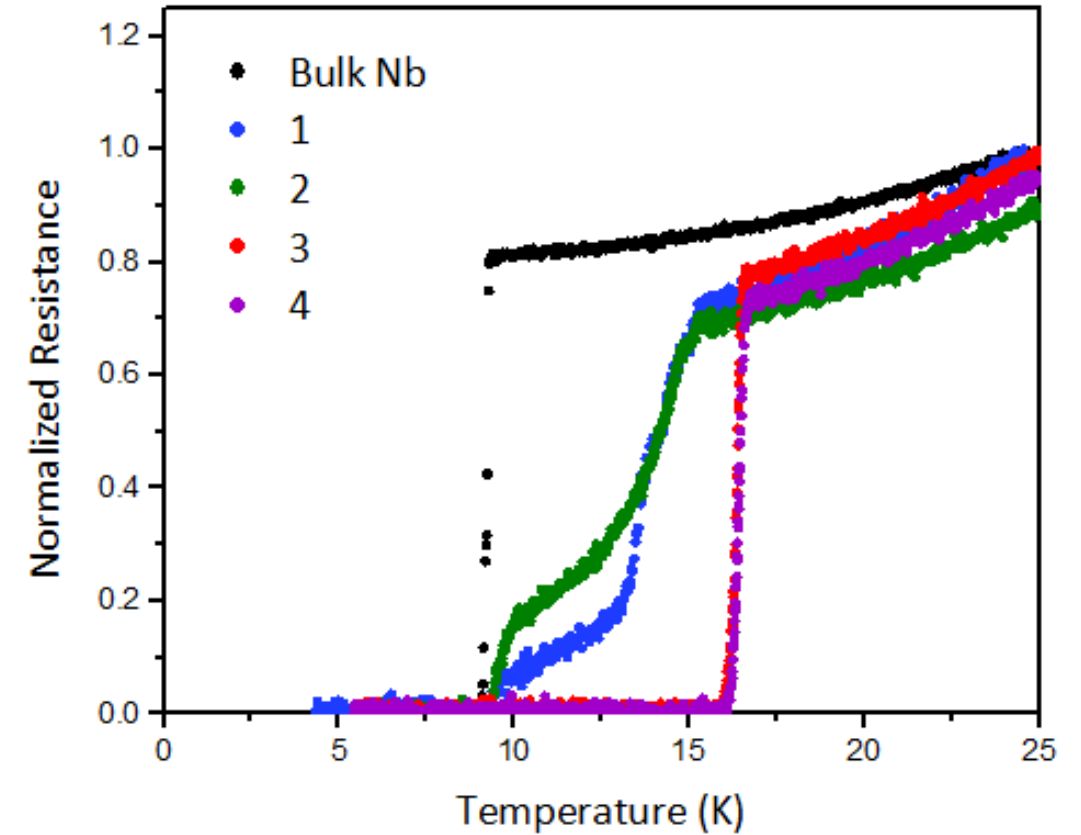
Sample #	Thickness (nm)	
	NbTiN	AlN
1	75	0
2	149	0
3	83	~10
4	166	~10
5	250	~10
6	371	~10



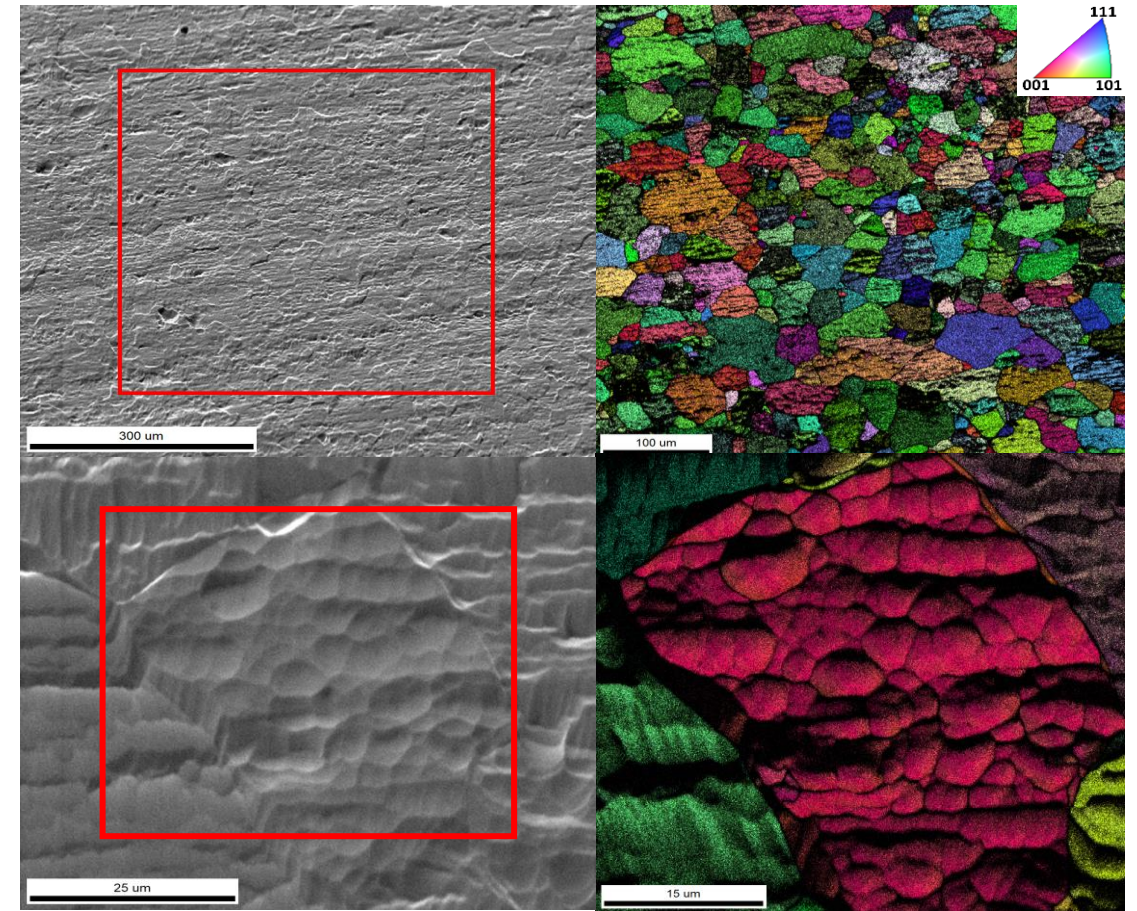
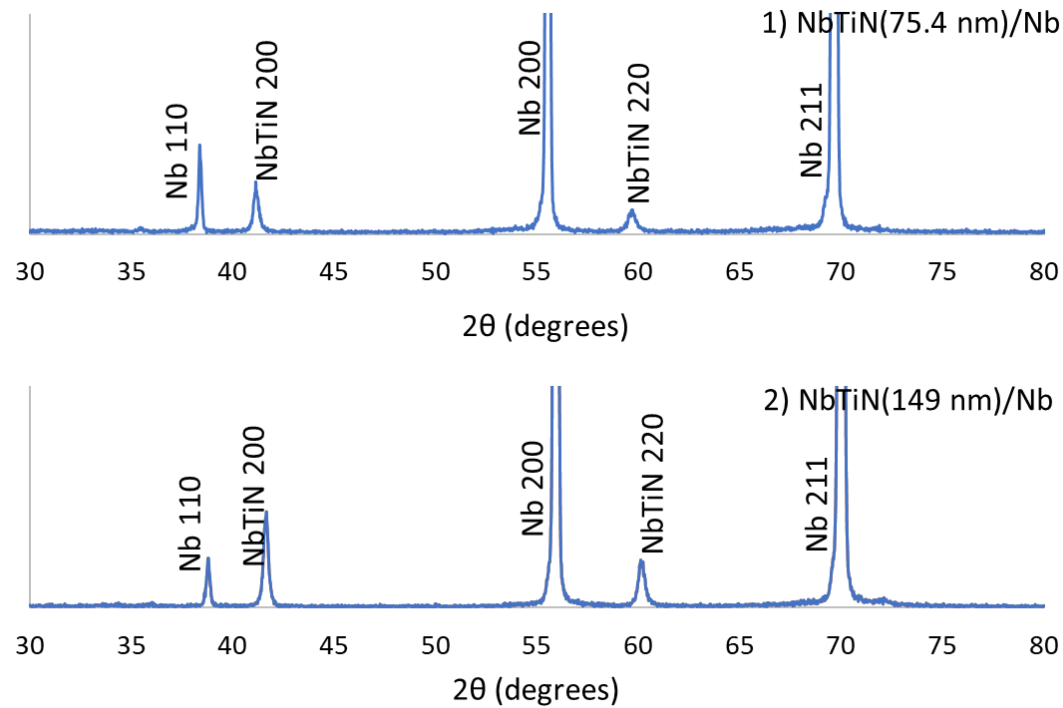
Cross-sectional transmission electron microscopy image of NbTiN/AlN/Nb structure
 A.-M. Valente-Feliciano et al, SRF2013

Resistance measurements done by standard four-point probe method

Sample #	Thickness (nm)		T _c (K)	ΔT (K)
	NbTiN	AlN		
1	75	0	16.2	0.40
2	149	0	16.3	0.30
3	83	~10	14.4	1.49
4	166	~10	15.7	0.79



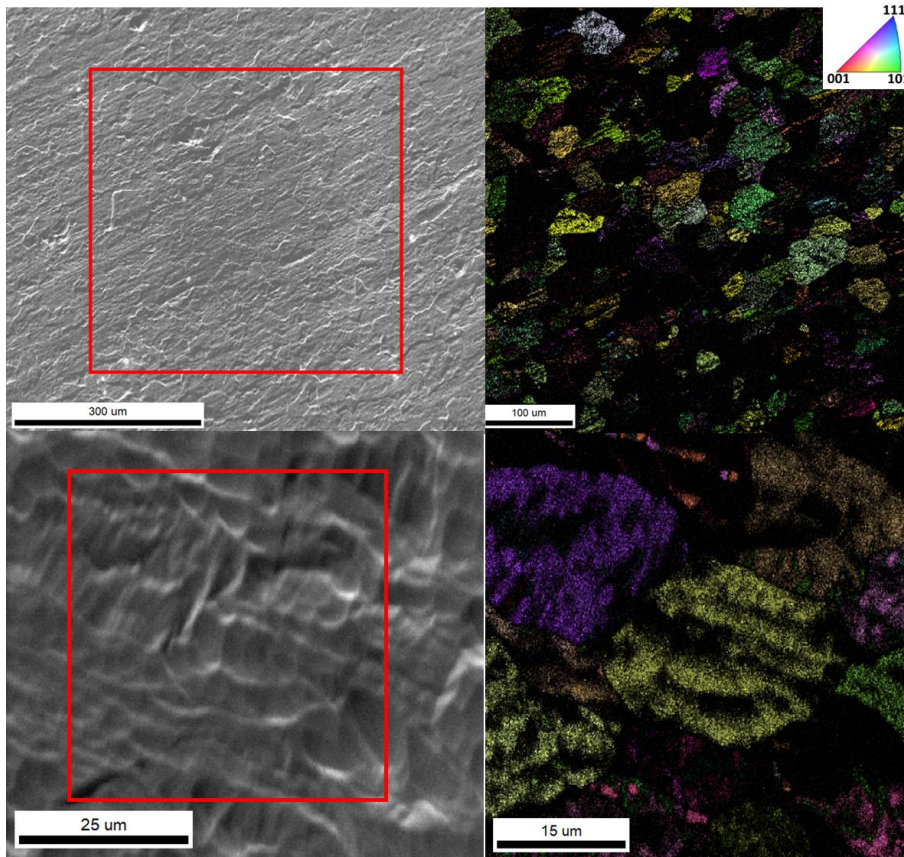
Single layer NbTiN on Nb substrate



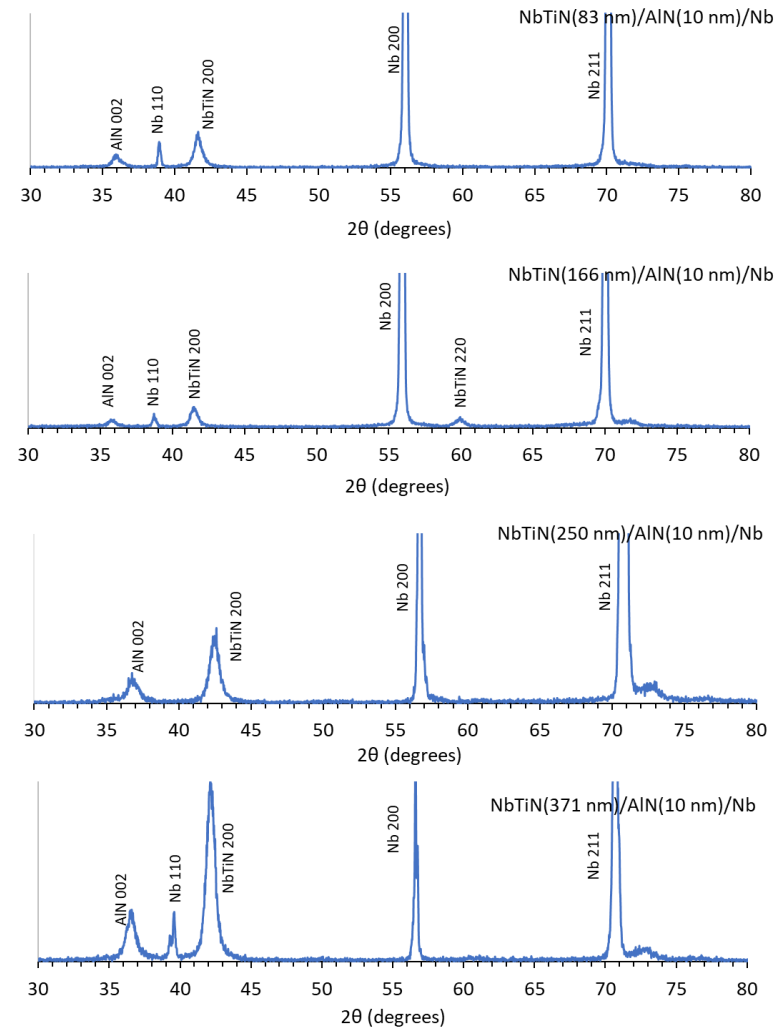
The crystallographic structures of deposited thin films were examined by X-ray diffraction (XRD) analysis

SEM images and relevant Inverse Pole Figure (IPF) map from EBSD showing the polycrystalline nature of the deposited film on bulk Nb

NbTiN/AlN on Nb Substrate



SEM images and relevant Inverse Pole Figure (IPF) map from EBSD showing the polycrystalline nature of the deposited film on bulk Nb



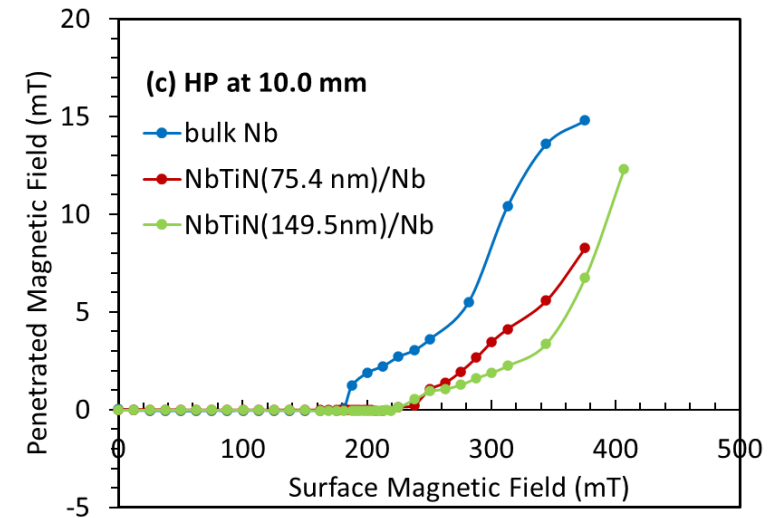
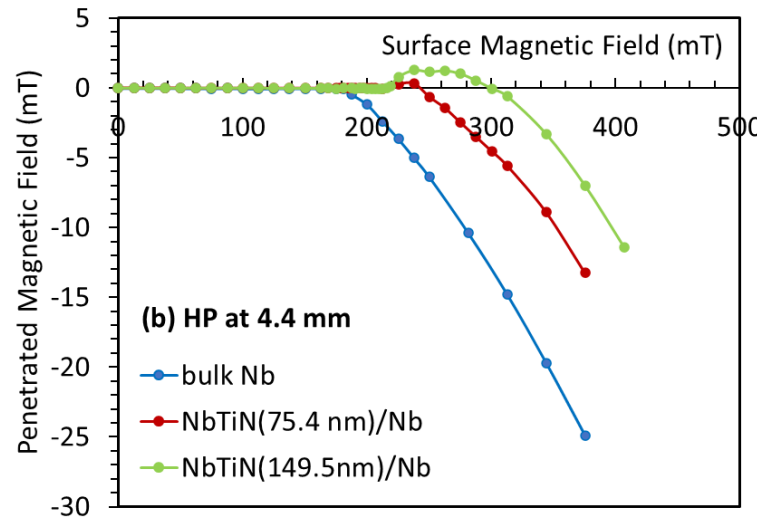
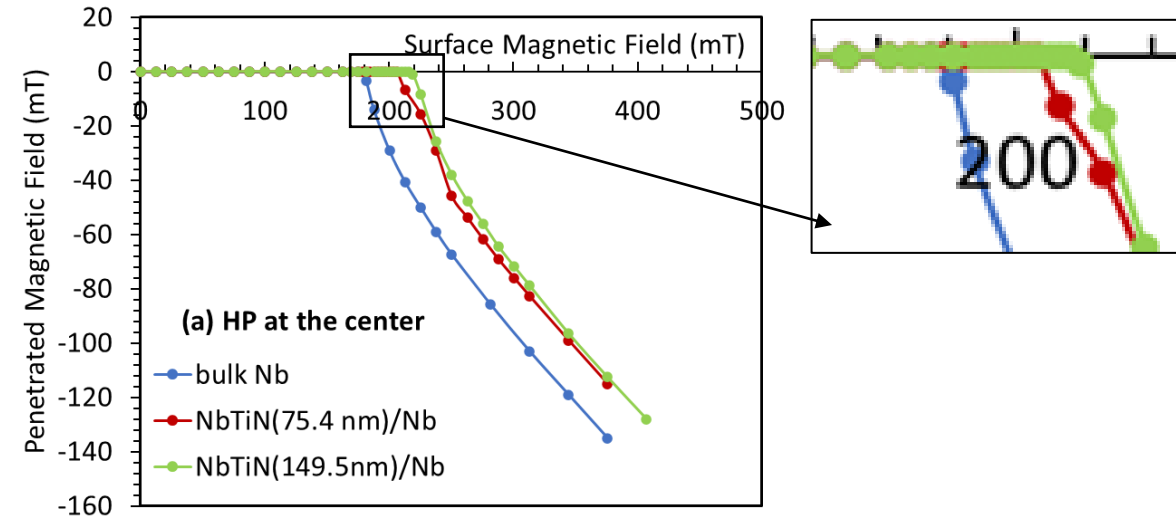
The crystallographic structures of deposited thin films were examined by X-ray diffraction (XRD) analysis

Single layer NbTiN on Nb substrate

Magnetic Field Penetration Measurements

At 4.35 K

Sample #	Thickness (nm)	
	NbTiN	AlN
1	75	0
2	149	0

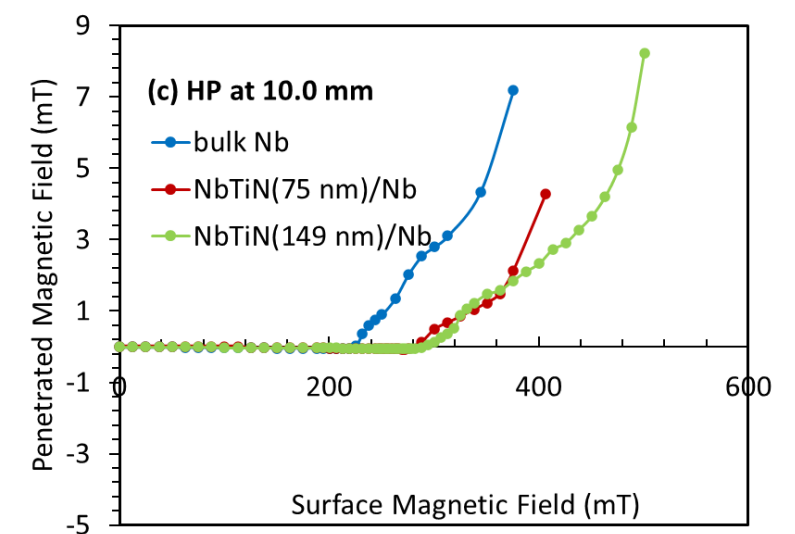
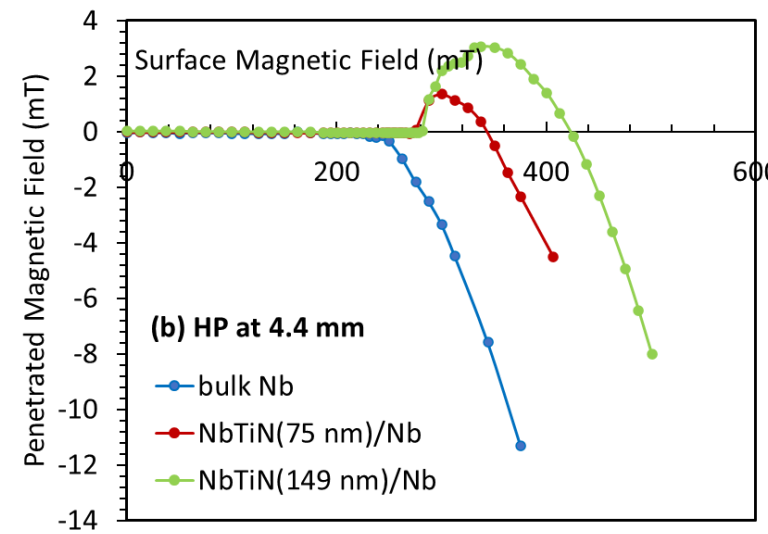
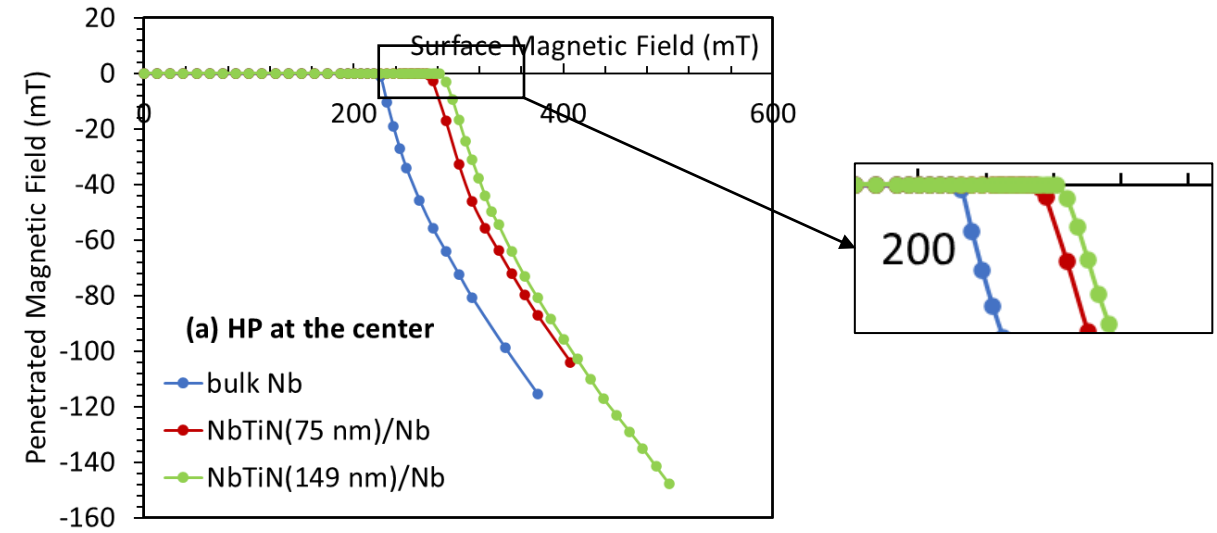


Single layer NbTiN on Nb substrate

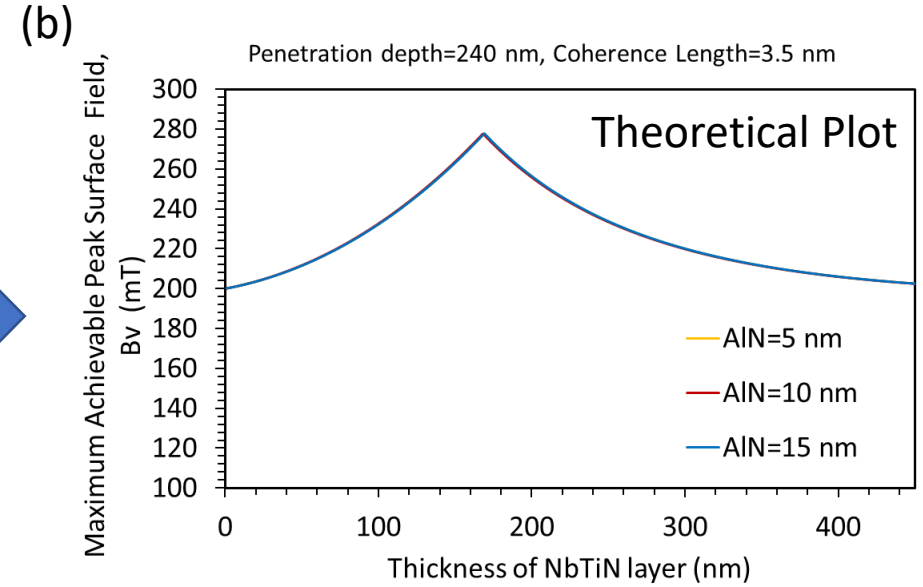
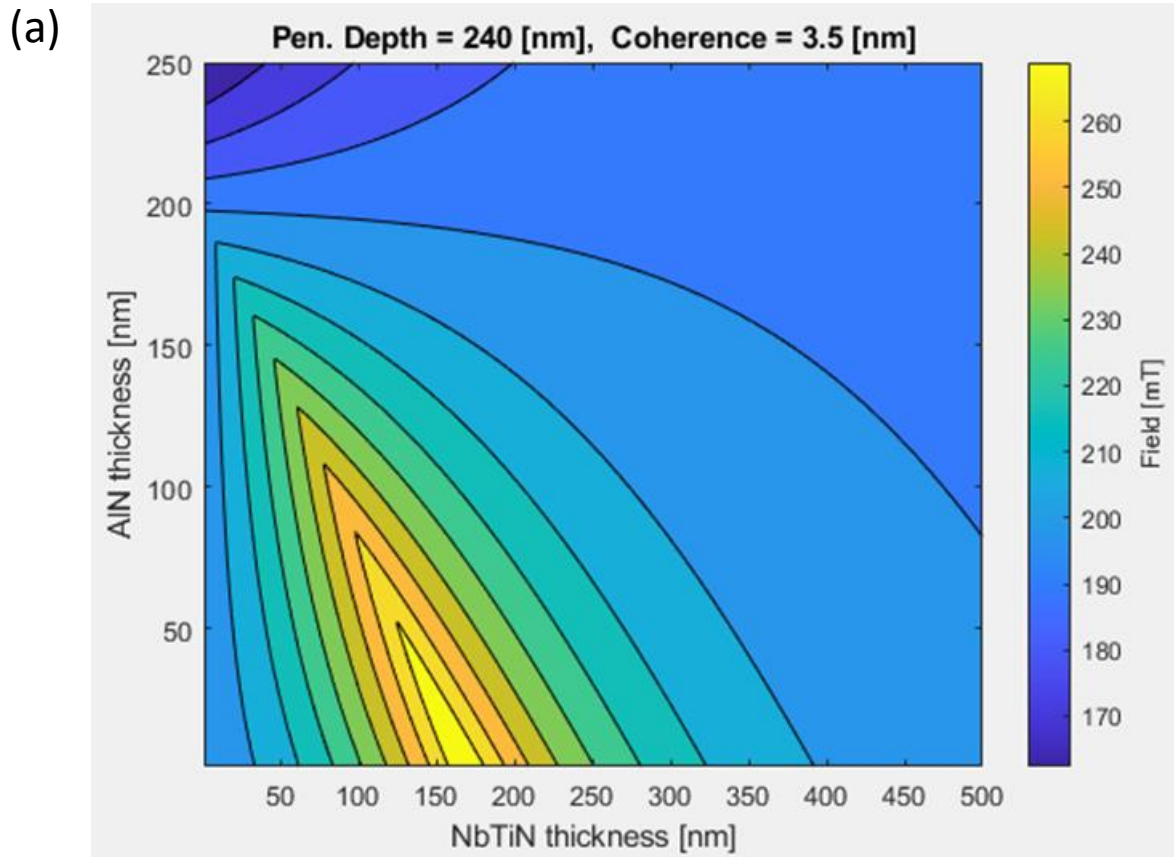
Magnetic Field Penetration Measurements

At 2.00 K

Sample #	Thickness (nm)	
	NbTiN	AlN
1	75	0
2	149	0



A Contour plot of the maximum achievable peak surface field, B_v



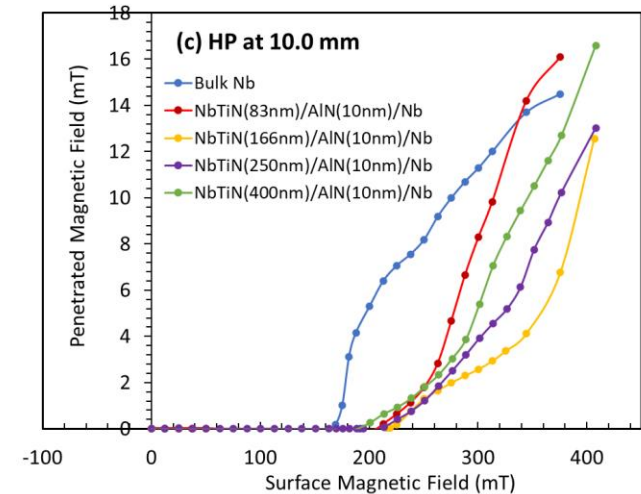
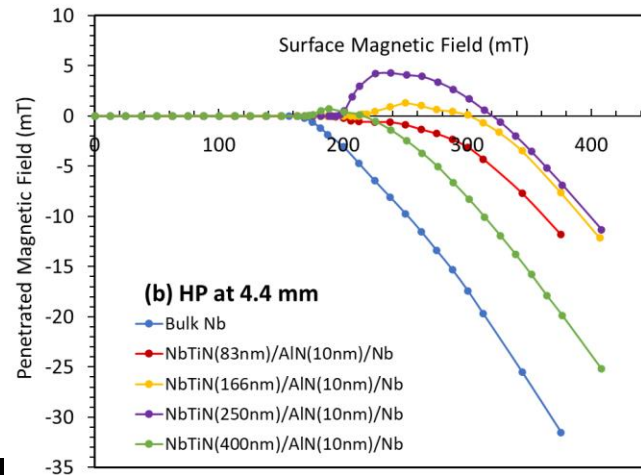
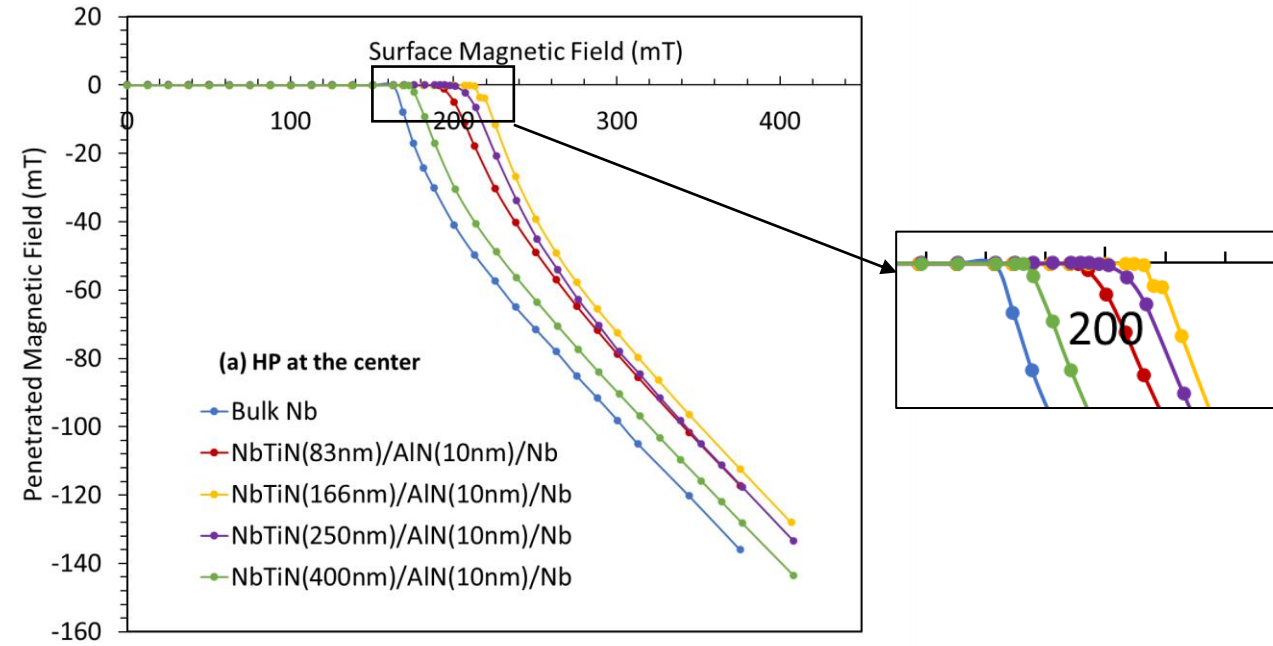
Equations in Ref. “ T. Kubo, Y. Iwashita, and T. Saeki, Applied Physics Letters **104**, 032603 (2014)” are used for this contour plot

Sample #	Thickness (nm)	
	NbTiN	AlN
3	83	~10
4	166	~10
5	250	~10
6	371	~10

NbTiN/AlN on Nb Substrate

Magnetic Field Penetration Measurements At 4.35 K

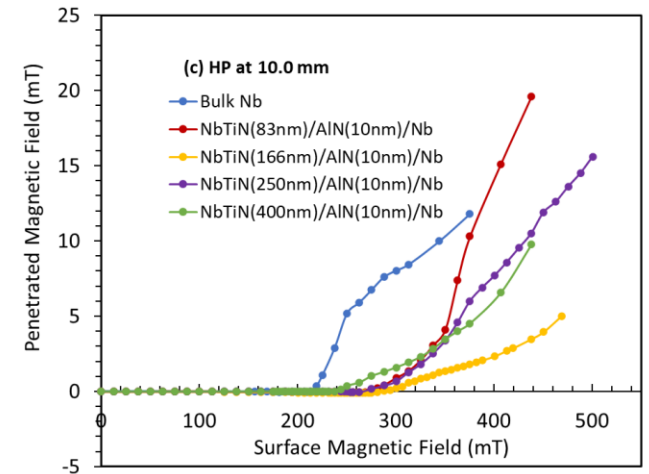
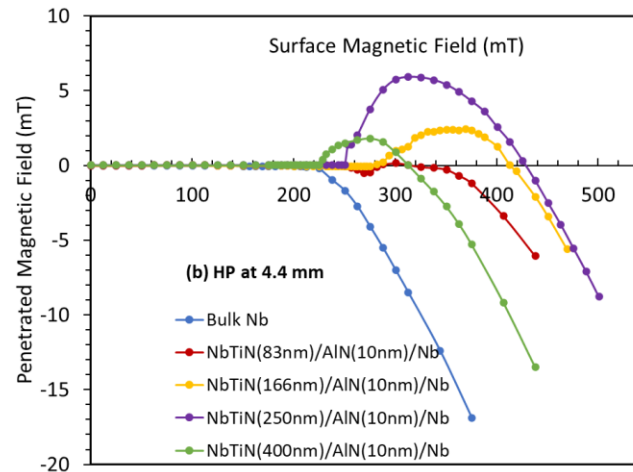
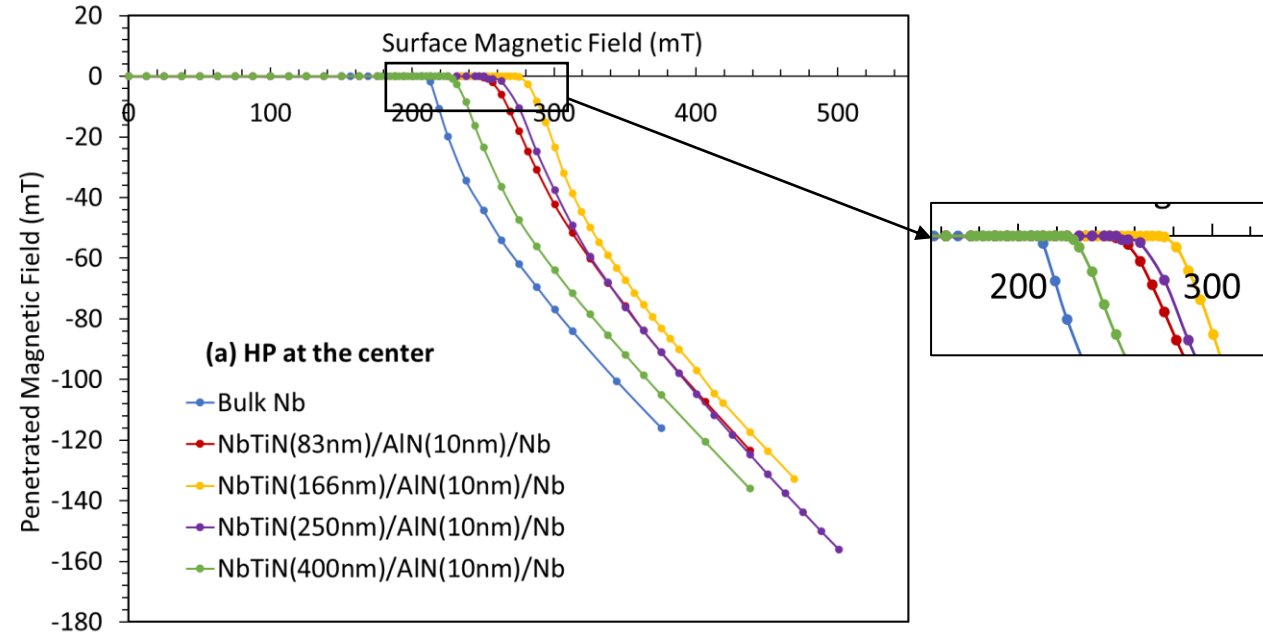
Sample #	Thickness (nm)	
	NbTiN	AlN
3	83	~10
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5	250	~10
6	371	~10



NbTiN/AlN on Nb Substrate

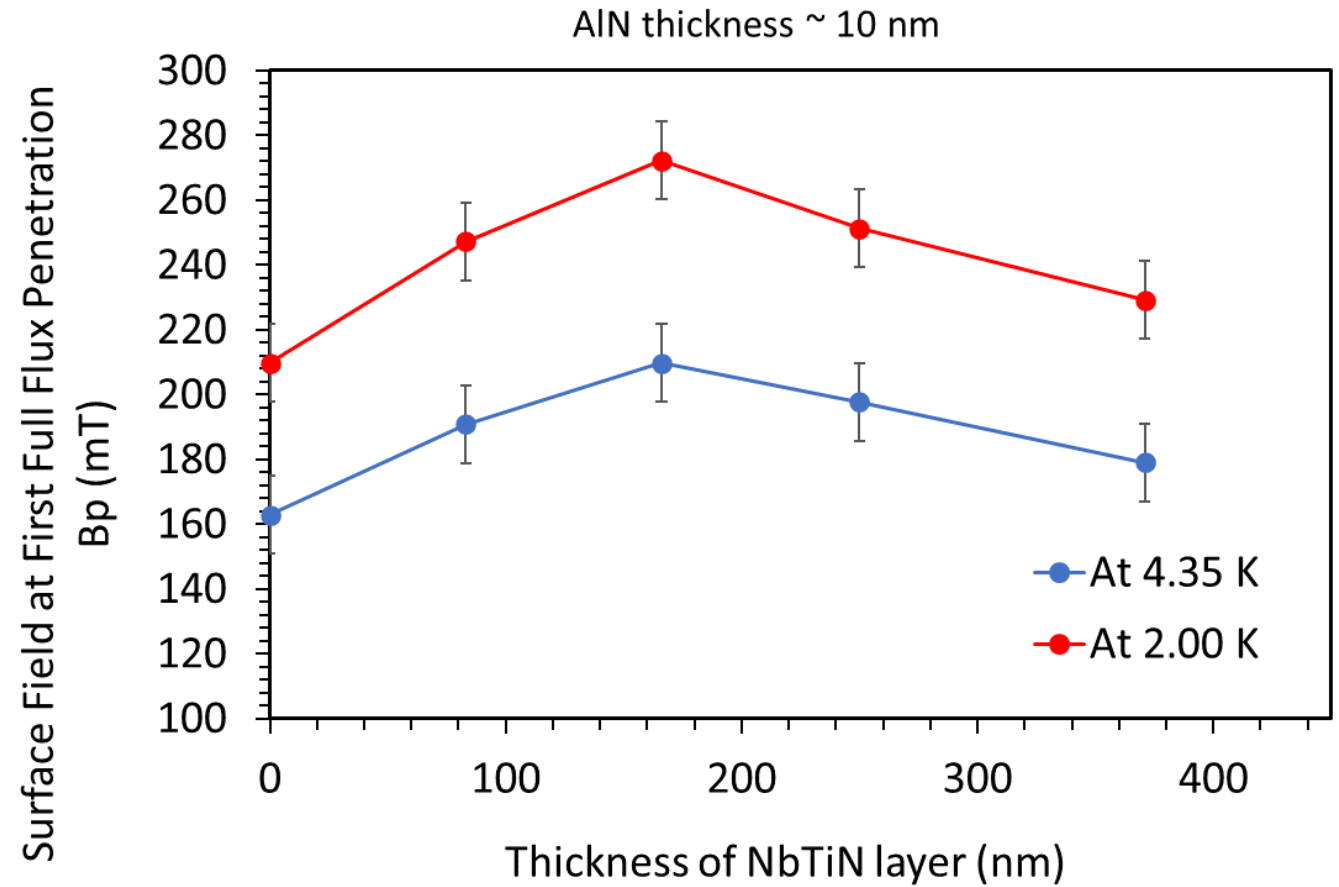
Magnetic Field Penetration Measurements At 2.00 K

Sample #	Thickness (nm)	
	NbTiN	AlN
3	83	~10
4	166	~10
5	250	~10
6	371	~10



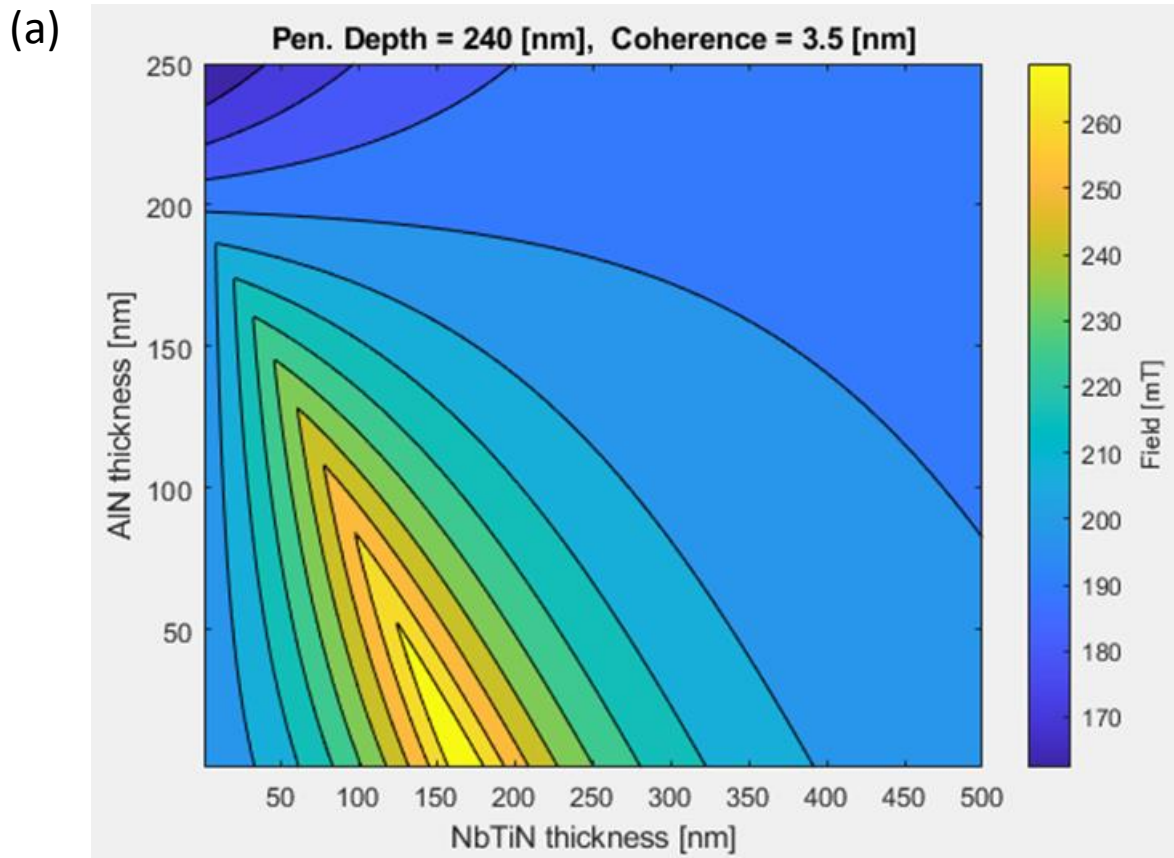
The surface field at first full flux penetration, B_p at 4.35 K and 2.00 K for different NbTiN layer thickness maintaining constant AlN layer thickness ~ 10 nm

Sample #	Thickness (nm)	
	NbTiN	AlN
3	83	~ 10
4	166	~ 10
5	250	~ 10
6	371	~ 10

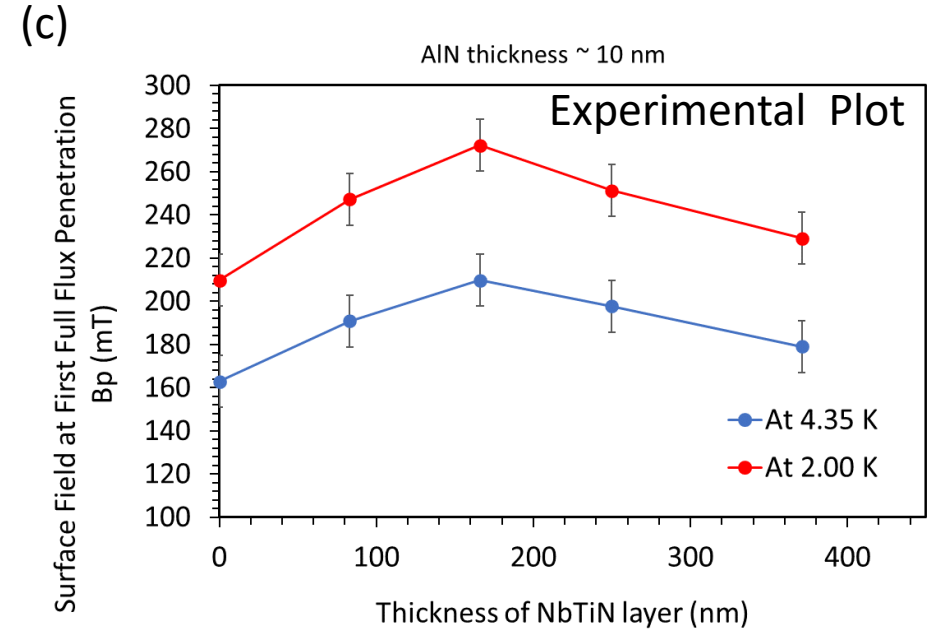
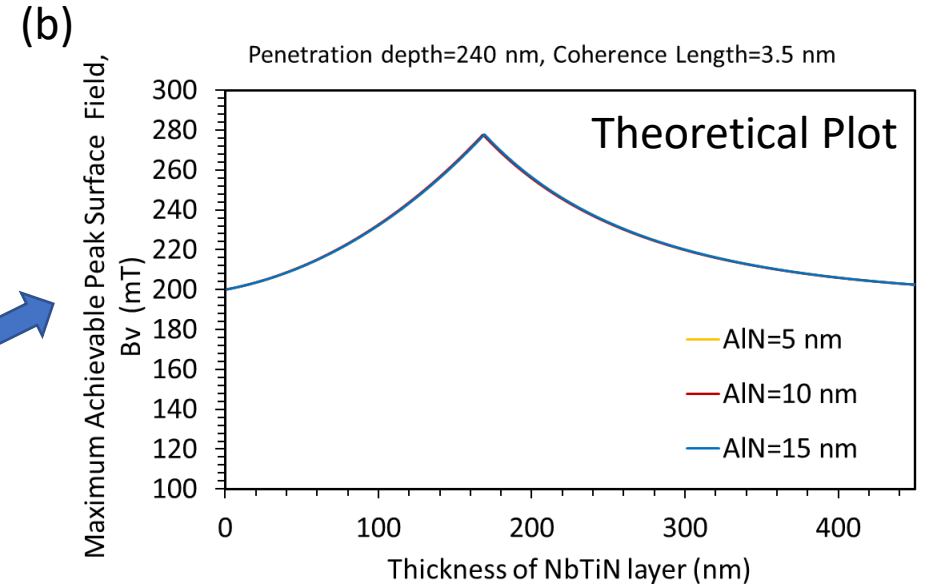


$\sim 25\%$ increase of B_p compared to bare Nb is observed with single NbTiN and single AlN layers on bulk Nb

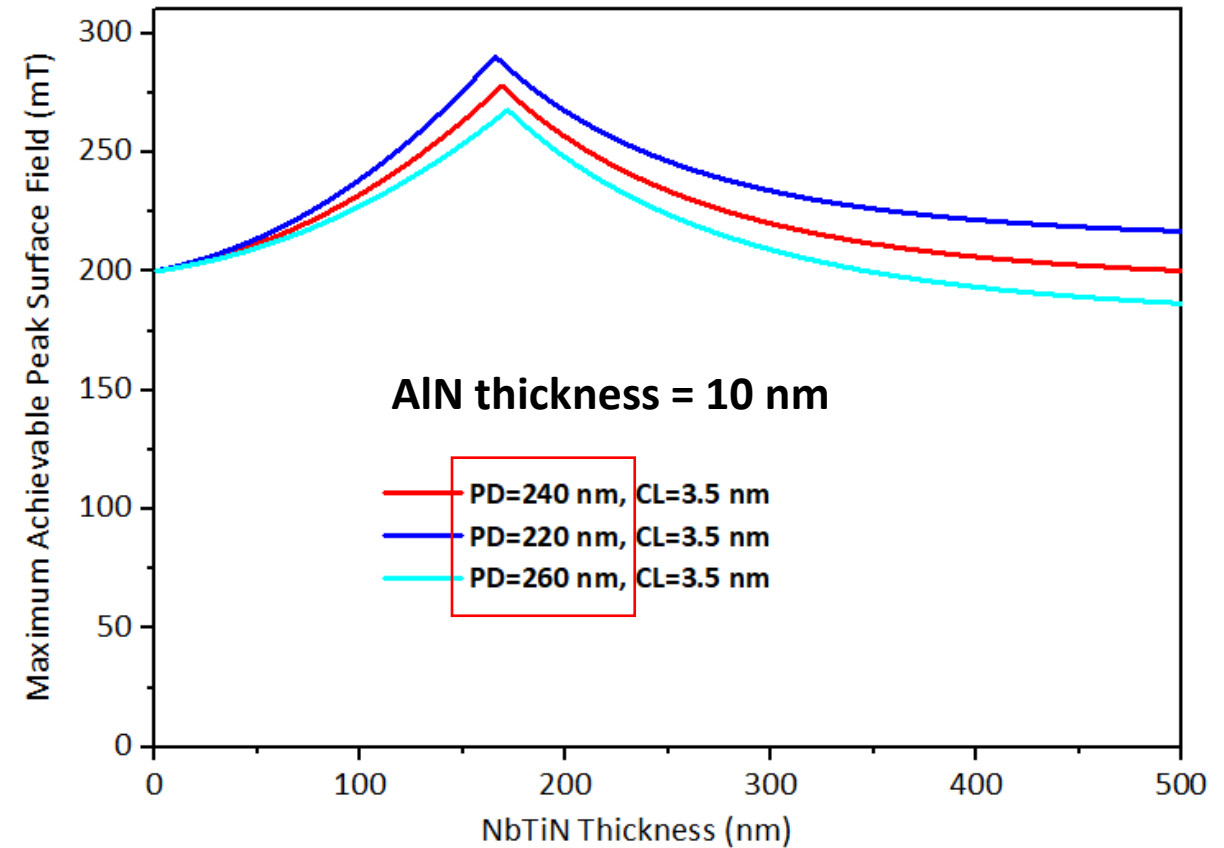
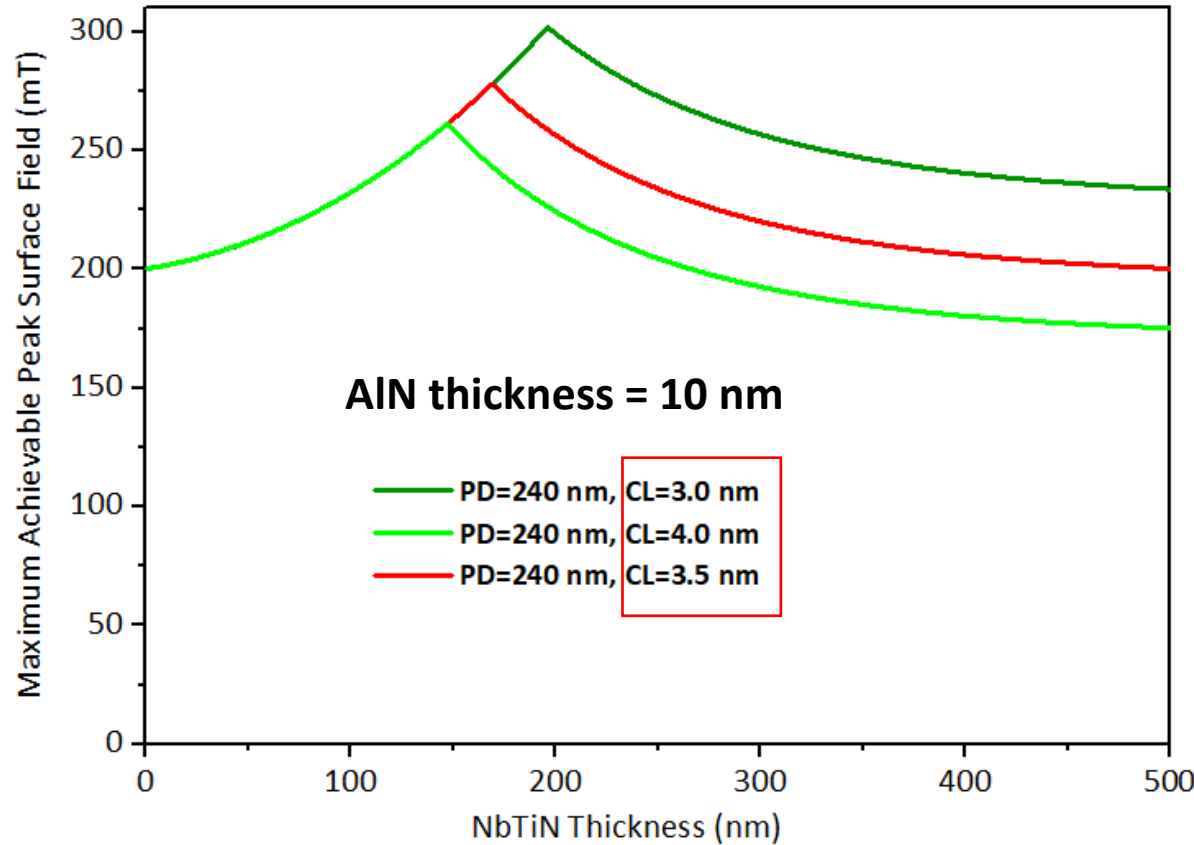
A Contour plot of the maximum achievable peak surface field, B_v



Equations in Ref. " T. Kubo, Y. Iwashita, and T. Saeki, Applied Physics Letters **104**, 032603 (2014)" are used for this contour plot



The peak of the graph depends on the penetration depth and the coherence length of the sample.

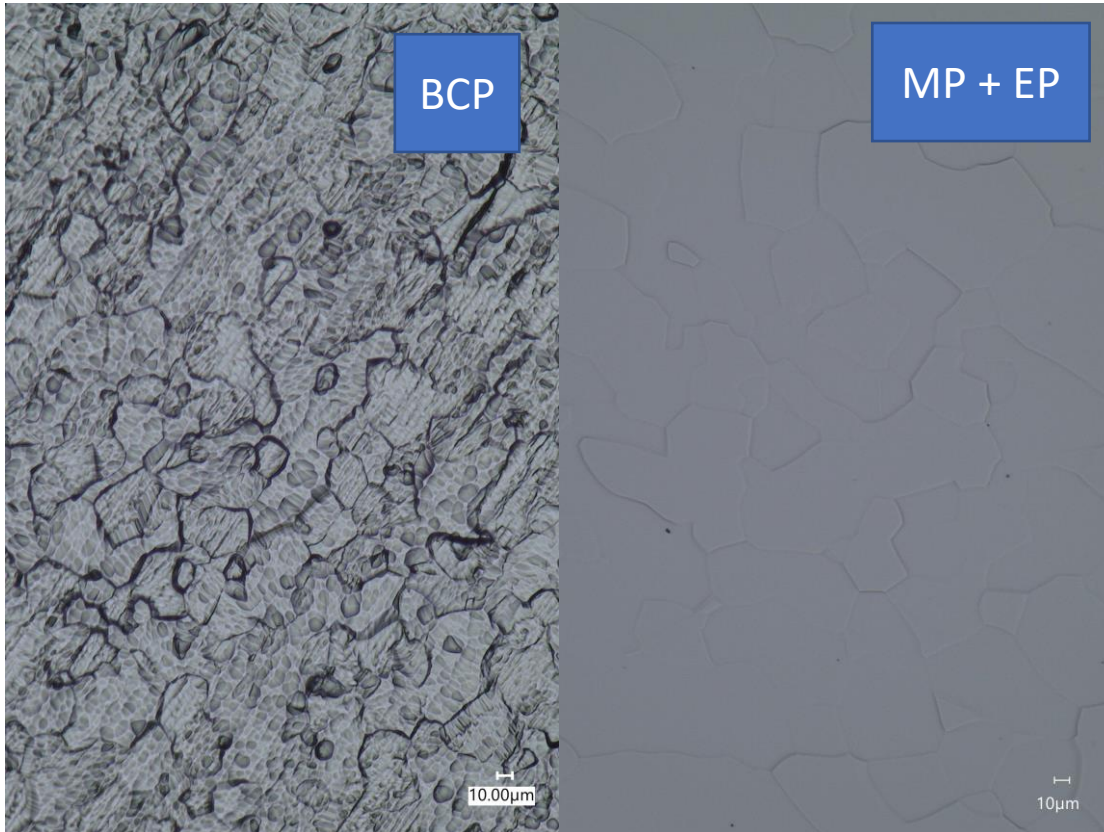


Conclusions

- Layered Nb showed flux penetration at higher field compared to bare Nb.
- To explore multilayer concept that has been proposed to enhance peak surface magnetic field of the SRF cavity,
a series of NbTiN/AlN coated on BCP Nb samples with
 - different NbTiN thickness
 - constant AlN thickness were tested.
- The variation of B_p confirms that the existence of optimum thickness of S layer for maximum field and that is consistent with the theory build up in “T. Kubo, Y. Iwashita, and T. Saeki, Applied Physics Letters **104**, 032603 (2014)”.
- Optimum thickness of NbTiN for maximum B_p among measured four thicknesses is 166 nm when AlN is nearly 10 nm.

Nb substrate with different roughness: BCP vs MP+ EP

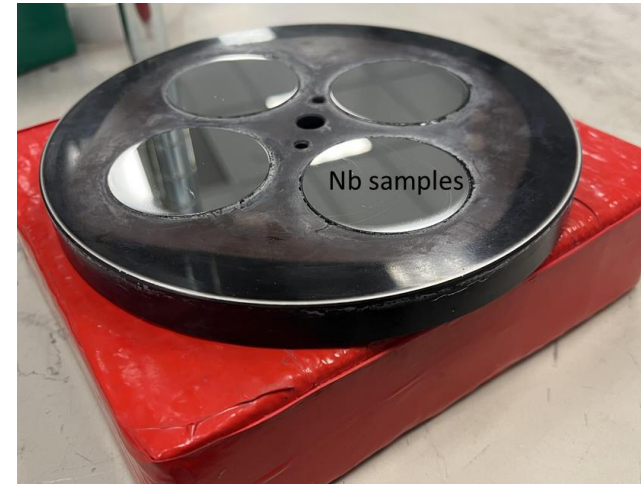
Optical Images



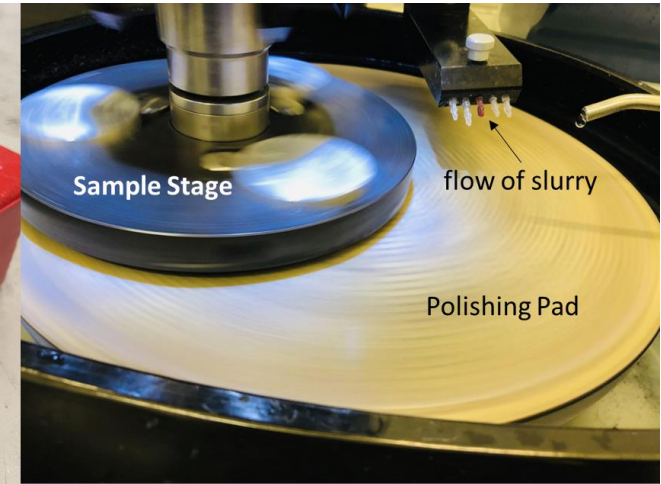
RMS roughness: $\sim 3 \mu\text{m}$
Substrate thickness $\sim 250 \mu\text{m}$

$\sim 20 \text{ nm}$
 $150 \mu\text{m}$

BCP- Buffered Chemical Polishing
EP - Electropolishing
MP- Mechanical Polishing



Mirror finished samples



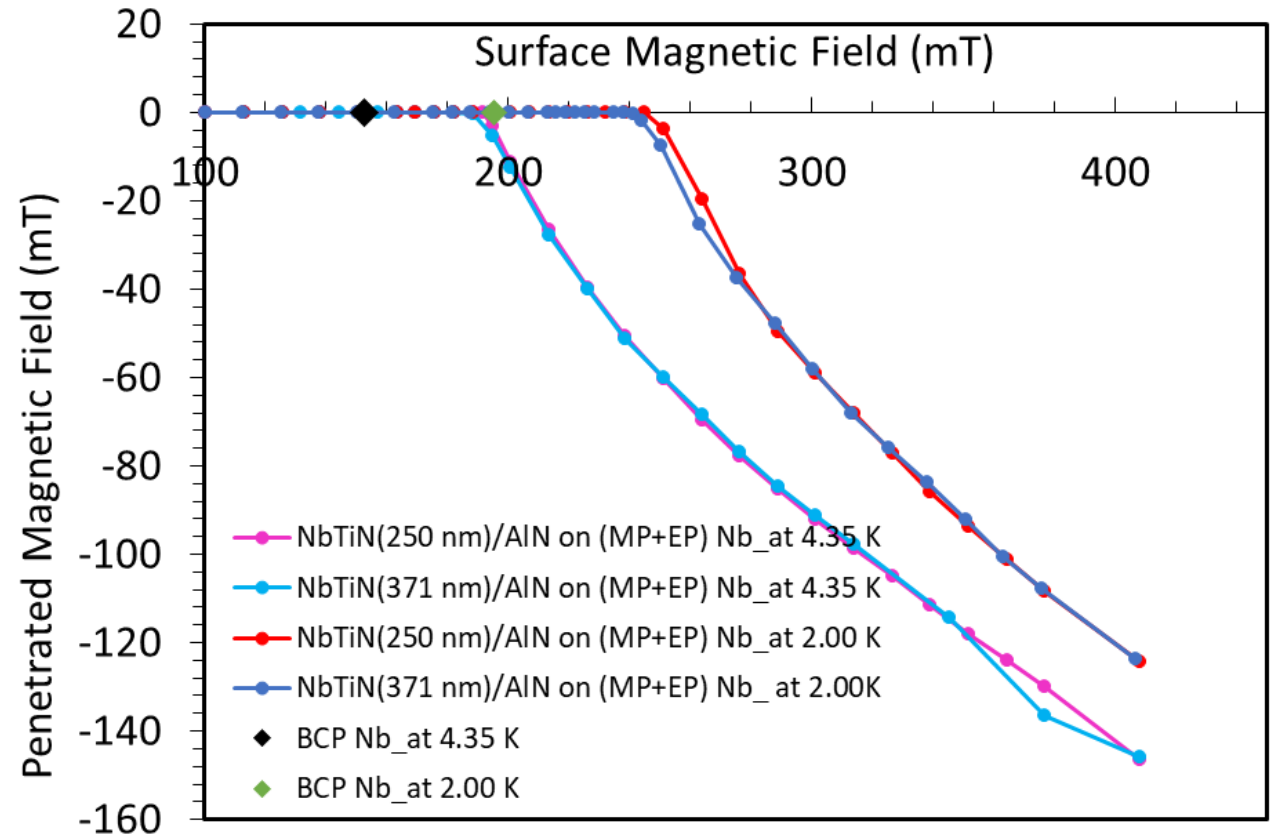
Sample stage is spinning on polishing pad with flow of slurry

NbTiN/AlN coated on MP+EP Nb substrate

Sample #	Thickness (nm)	
	NbTiN	AlN
5	250	~10
6	371	~10

5-10 % increase is estimated compared to multilayer coated on BCP Nb

Magnetic Field penetration measurements



Thank You !

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